Fully-Integrated Ultra-Wideband Radar System for Medical Imaging

by

Shengkai Gao

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Abstract

Ultra-wideband (UWB) technology has attracted the attention of the industry and research community since the 3.1-10.6 GHz band spectral regulation was declassified for commercial use by the Federal Communications Commission (FCC) in 2002. UWB technology has positioned itself as a promising candidate for implementing shortrange high-data-rate wireless communication systems, wireless sensor networks, and high-resolution radar/imaging systems because of the availability of large 7.5-GHz bandwidth, simple transceiver architecture, low power consumption, and robustness against narrowband interference. For the widespread adoption of UWB technology in wireless communication and radar systems, it is essential to develop fully-integrated cost-effective low-power UWB transceivers. Among all the fabrication methods, the complementary metal-oxide-semiconductor (CMOS) process stands out as a technology for implementing UWB circuits with low cost, low power consumption, and a high level of integration. As CMOS technology advances with higher transit frequency (f_T) but lower normal operation voltage, the maximum energy available from a single UWB pulse is further limited. Thus the design of long-range UWB transceiver systems becomes more and more challenging.

The objective of this thesis is to implement a single-chip, meter-range UWB radar system in CMOS technology. Like a narrowband transceiver system, the transmission and detection range of the UWB system is positively related to the power (amplitude) of the transmitted signal. The first part of the research focuses on designing a UWB transmitter with high amplitude and low complexity. Implemented in 65-nm CMOS technology, two UWB transmitters capable of generating UWB pulses with a peak-to-peak amplitude (V_{pp}) more than two times the supply voltage are presented. Shifting the UWB signal synthesis to the digital domain using trapezoidal waves, the first design requires only a simple low-loss passive filter to conform to the UWB spectral regulations. The second design seeks to generate a higher output amplitude utilizing a wideband passive amplification technique. The second part of the research concentrates on the design and implementation of a correlation-based UWB radar receiver which is composed of a UWB single-ended-to-differential low-noise amplifier, a delay-locked loop with a minimum delay step of 20 ps and a period of 5.12 ns, a local replica generator that has the same structure as the first transmitter design, and a multiplier-based analog correlator. Reported simulation results verify the performance of the proposed UWB receiver and its building blocks.

Preface

This thesis is an original work by Shengkai Gao.

Chapter 3.1 of this thesis has been published as S. Gao and K. Moez, "A 2.12-V V_{pp} 11.67-pJ/pulse Fully Integrated UWB Pulse Generator in 65-nm CMOS Technology," IEEE Transactions on Circuits and Systems I: Regular Papers, vol. 67, no. 3, pp. 1058–1068, 2019.

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Table of Contents

1	Intr	duction 1
	1.1	Medical Imaging of Breast Cancer
	1.2	Ultra-Wideband Technology
	1.3	UWB Medical Imaging 7
	1.4	Thesis Overview
2	UW	3 Transmitter and Receiver Topologies 13
	2.1	UWB Pulse Generation Structures 14
		2.1.1 Digitally-Delayed Impulse Combination
		2.1.2 Oscillator-Based Pulse Generator
		2.1.3 Pulse Derivation
		2.1.4 Spectrum Filtering
	2.2	Consideration of UWB Pulse Generation
	2.3	UWB Receiver Structures 20
		2.3.1 Energy Envelope Detection
		2.3.2 Cross-Correlation Detection
		2.3.3 Auto-Correlation Detection
		2.3.4 Direct Sampling Detection
		2.3.5 Sub-Sampling Detection
	2.4	Consideration of UWB Signal Detection

3 UWB Transmitters

	3.1	A Hig	h-Amplitude UWB Pulse Generator with Spectrum Controlled	
		by Dig	gital Synthesis	27
		3.1.1	Digital Synthesis of the Input UWB Pulse	27
		3.1.2	Trapezoidal-Wave-Driven Power Amplifier Circuit Analysis	32
		3.1.3	Circuit Implementation and MOSFET Sizing	41
		3.1.4	Measurement Results	43
	3.2	A Hig	h-Voltage UWB Pulse Generator using Passive Amplification in	
		65-nm	CMOS	47
		3.2.1	Ultra-Wideband Passive Amplification	48
		3.2.2	Proposed UWB Pulse Generator Design	50
		3.2.3	Measurement results	66
	3.3	Conclu	usion	69
4	UW	B Red	ceiver and Radar System	70
	4.1	UWB	Radar System Structure	70
	4.2	Ultra-	Wideband Low-Noise Amplifier	72
	4.3	Local	Template UWB Signal Generator	82
	4.4	Delay	Locked Loop Design	84
		4.4.1	Phase/frequency Detector	84
		4.4.2	Charge Pump	90
		4.4.3	Voltage-Controlled Delay Line Design	97
		4.4.4	Transfer Function of the DLL	107
	4.5	Correl	lator Design	109
	4.6	UWB	radar system implementation and simulation	112
	4.7	Summ	nary	116
5	Cor	nclusio	ns	118
	5.1	Summ	nary of Contributions	118
	5.2	Future	e Work	120

Bibliography

List of Tables

3.1	Zeros created in the wave spectrum for $N = 0, 1, 2, 3. \ldots$	30
3.2	Summary of performance and comparison with previously reported	
	UWB pulse generators	47
3.3	Component values of the proposed passive network	63
3.4	Summary of performance and comparison with previously reported	
	UWB pulse generators	68
4.1	Power consumption summary of the sub-circuits in the proposed UWB	
	radar system.	116

List of Figures

1.1	FCC regulation for an indoor environment.	5
1.2	Time domain narrowband and UWB signals and the corresponding	
	spectrum in the frequency domain.	5
1.3	Microwave imaging by analyzing the signal transmitted through the	
	breast	8
1.4	Microwave imaging by analyzing the signal reflected from the breast.	9
1.5	Confocal microwave imaging demonstration.	10
1.6	Cross-correlation UWB radar system block diagram.	11
1.7	Cross-correlation detection demonstration	11
2.1	The signal is UWB signal if $f_H - f_L > 0.2 \frac{(f_H + f_L)}{2}$	13
2.2	Digitally-delayed positive- and negative-peak impulse combination	15
2.3	Oscillator-based pulse generator	16
2.4	UWB pulse generation by taking the derivative of the pulse's rising	
	and falling edges.	16
2.5	UWB pulse generation by spectrum filtering	17
2.6	(a) Transmit-receive system, and (b) transmit-reflect-receive system	18
2.7	Energy detection block diagram	20
2.8	Cross-correlation receiver block diagram	21
2.9	(a) Auto-correlation receiver block diagram, and (b) time domain sig-	
	nals of path1 and path2	23
2.10	(a) Direct sampling detection, and (b) time domain signals	24

2.11	Sub-sampling detection technique	25
3.1	Time-domain signal and normalized spectrum. (a) A step signal, (b)	
	single trapezoidal wave, and (c) two consecutive trapezoidal waves.	28
3.2	PSD of two trapezoidal waves and a single trapezoidal wave (50 $\rm ns$	
	repetition period).	31
3.3	Two consecutive trapezoidal waves with varying τ_r . (a) Time-domain	
	signal, and (b) normalized spectrum.	31
3.4	(a) Trapezoidal wave driven circuit, and (b) equivalent circuit	32
3.5	$V_{GS}(t)$, $V_{DS}(t)$ and $I_{DS}(t)$ for $L_1=1\mu$ H. (a) Time-domain signal, and	
	(b) normalized spectrum	34
3.6	$V_{GS}(t), V_{DS}(t)$ and $I_{DS}(t)$ for $L_1=1.5$ nH. (a) Time-domain signal, and	
	(b) normalized spectrum	36
3.7	(a) Equivalent RLC circuit, and (b) damping with varying L_1	38
3.8	(a) $I_{DS}(t)$ with varying load inductance, (b) triangular shape $I_{DS}(t)$	
	assumption, (c) output spectrum with varying load inductance ($\tau_r=30$	
	ps), and (d) Output spectrum with a 1.5-nH load inductor and varying	
	$ au_r$	39
3.9	(a) Proposed pulse generator circuit, (b) network frequency response,	
	and (c) signal flow	42
3.10	$I_{DS}(t)$ with different MOSFET widths	43
3.11	Microphotograph of the fabricated chip.	43
3.12	On-wafer output measurement setup	44
3.13	Time-domain simulation and measurement of the output pulse	45
3.14	Spectrum simulation and measurement of the output pulse	45
3.15	Breakdown time t_{BD} versus oxide voltage V_{ox} for 2.2-nm oxide thickness	
	t_{ox}	46
3.16	Passive amplification demonstration.	48

3.17	UWB pulse generator block diagram	51
3.18	(a) Pulse generator with RFC and DC block capacitor, (b) OFF and	
	ON state of the circuit	52
3.19	(a) $V_{DS}(t)$ with varying load resistance R_L (width of MOSFET is 320	
	μ m), (b) normalized spectrum of V_{R_L} , (c) single pulse energy E_1 , and	
	(d) single pulse energy located from 3.1 to 10.6 GHz E_2	54
3.20	(a) Pulse generator with finite inductor and a parallel capacitor, (b)	
	OFF and ON state of the circuit.	56
3.21	Wideband matching in a Smith chart	57
3.22	Impedance matching when M_1 is ON	58
3.23	Impedance matching when M_1 is OFF	59
3.24	Second-order passive network model	59
3.25	Schematic of the proposed pulse generator	61
3.26	Z_{IN} and Z'_{IN} of the proposed matching network	62
3.27	Butterworth 3rd-order bandpass filter.	62
3.28	Time domain signals with the proposed matching network and the	
	3rd-order Butterworth bandpass filter	63
3.29	Spectrum of the output signals with the proposed matching network	
	and the 3rd-order Butterworth bandpass filter	64
3.30	(a) Layout of the 4×200-fF capacitor, (b) layout of the 800-fF capac-	
	itor, (c) Momentum simulated capacitance of the two capacitors, and	
	(d) Momentum simulated quality factor.	65
3.31	Chip microphotograph	66
3.32	Measurement setup	66
3.33	Time domain waveform measurement	67
3.34	Measured power spectral density results	67
<u>4</u> 1	UWB radar system block diagram	71
т. т	C II D Iadai System Stock diagram.	11

4.2	N-stage cascaded devices chain	72
4.3	(a) First stage of the LNA, and (b) simplified circuit model. \ldots .	73
4.4	Noise contributed by (a) R_1 , and (b) $M_{1n,1p}$.	75
4.5	Schematic of the proposed LNA	76
4.6	LNA gain demonstration.	76
4.7	Transformer model circuit	77
4.8	(a) Transformer structure, (b) coupling coefficient k simulation result,	
	(c) self-inductances of L_p and L_s , and (d) quality factor Q of the sec-	
	ondary winding	79
4.9	S11 of the proposed LNA.	81
4.10	Voltage gain the of the LNA.	81
4.11	Noise figure of the LNA.	81
4.12	(a) UWB transmitter and local template generator circuits, (b) new	
	delay control circuit, and (c) signal flow of local template generator	
	including integration-window generator	82
4.13	PFD circuit	85
4.13 4.14	PFD circuit. .	85 85
4.134.144.15	PFD circuit. .	85 85 86
4.134.144.154.16	PFD circuit. . <t< td=""><td>85 85 86 87</td></t<>	85 85 86 87
 4.13 4.14 4.15 4.16 4.17 	PFD circuit.	 85 85 86 87 88
 4.13 4.14 4.15 4.16 4.17 4.18 	PFD circuit.	85 85 86 87 88 88
 4.13 4.14 4.15 4.16 4.17 4.18 4.19 	PFD circuit. \cdots Timing diagram of the PFD.PFD design in [66]PFD correct lock and harmonic false lock.PFD stuck false lock.PFD stuck false lock.Correct stuck false lock by resetting at the falling edge of CLK_{ref} .Proposed PFD with false lock prevention.	 85 85 86 87 88 88 88 89
 4.13 4.14 4.15 4.16 4.17 4.18 4.19 4.20 	PFD circuit. \cdots Timing diagram of the PFD.PFD design in [66]PFD correct lock and harmonic false lock.PFD stuck false lock.PFD stuck false lock.Correct stuck false lock by resetting at the falling edge of CLK_{ref} .Proposed PFD with false lock prevention.(a) Charge pump circuit with the PFD block and load capacitor, and	85 85 86 87 88 88 88 89
 4.13 4.14 4.15 4.16 4.17 4.18 4.19 4.20 	PFD circuit	85 85 86 87 88 88 88 89 90
 4.13 4.14 4.15 4.16 4.17 4.18 4.19 4.20 4.21 	PFD circuit	 85 85 86 87 88 88 89 90
 4.13 4.14 4.15 4.16 4.17 4.18 4.19 4.20 4.21 	PFD circuit. \cdots Timing diagram of the PFD.PFD design in [66]PFD correct lock and harmonic false lock.PFD stuck false lock.PFD stuck false lock.Correct stuck false lock by resetting at the falling edge of CLK_{ref} .Proposed PFD with false lock prevention.(a) Charge pump circuit with the PFD block and load capacitor, and(b) waveform with phase difference and locked state.(a) "Drain-switched" charge pump circuit, and (b) charge pump cur-rent matching characteristic.	 85 85 86 87 88 89 90 92
 4.13 4.14 4.15 4.16 4.17 4.18 4.19 4.20 4.21 4.22 	PFD circuitTiming diagram of the PFD.PFD design in [66]PFD correct lock and harmonic false lock.PFD correct lock and harmonic false lock.PFD stuck false lock.PFD stuck false lock.Correct stuck false lock by resetting at the falling edge of CLK_{ref} .Proposed PFD with false lock prevention.(a) Charge pump circuit with the PFD block and load capacitor, and(b) waveform with phase difference and locked state.(a) "Drain-switched" charge pump circuit, and (b) charge pump cur-(a) Charge pump circuit with improved current mismatch from [71],	 85 85 86 87 88 88 89 90 92

4.23	Charge pump with transit current mismatch and possible solution $\ .$	94
4.24	Proposed charge pump with improved current mismatch. \ldots .	95
4.25	Current matching of the sourcing and sinking current	96
4.26	Transit waveforms of the sourcing and sinking current with and without	
	C_1	96
4.27	M-stage delay chain	98
4.28	(a) Inverter MOSFET circuit, and (b) the corresponding switch models	
	when V_{IN} is "LOW" and "HIGH"	99
4.29	Composition of load capacitance C_L at V_{OUT}	99
4.30	Voltage control delay line with multiplexer	.02
4.31	Simulation result of T_{VCDL} varying with V_{ctrl}	.04
4.32	(a) DLL design with single-chain 256-stage VCDL, and (b) DLL design	
	with 16×16 coarse-and-fine step control. $\ldots \ldots \ldots$.05
4.33	(a) DLL model, and (b) DLL response	.08
4.34	(a) Correlator model, (b) integrator implemented with low pass filter,	
	(c) integrator implemented with integration window controlled by switch.	.09
4.35	Correlator topology	.11
4.36	System signal flow (assuming the propagation time is less than 5.12 ns).1	13
4.37	Layout of the UWB radar system	.14
4.38	(a) Simulated local template signal and RF_1 signal (one output from	
	the transformer), (b) zoomed local template signal and RF_1 signal with	
	duration about $6 \times T_{VCDL}$, (c) the difference of the output signals from	
	the correlator	15

Abbreviations

- ADC analog-to-digital converter.
- **BPM** bi-phase modulation.
- **BPSK** binary phase-shift keying.
- CMI confocal microwave imaging.
- CMOS complementary metal-oxide-semiconductor.
- $\mathbf{CS}\xspace$ common source.
- DAC digital-to-analog converter.
- **DLL** delay-locked loop.
- **EIRP** effective isotropic radiated power.
- **EIT** electrical impedance tomography.
- **ETS** equivalent-time sampling.
- **FBW** fractional bandwidth.
- FCC Federal Communications Commission.
- **FSPL** free-space path loss.
- **GMP** Gaussian monocycle pulse.

GSPS Giga samples per second.

- **IFFT** Inverse Fourier transform.
- **ITU** International Telecommunication Union.
- **KCL** Kirchhoff's current law.
- KVL Kirchhoff's voltage law.
- LNA low-noise amplifier.
- LO local oscillator.
- NF noise figure.
- PDK process design kit.
- **PFD** phase/frequency detector.
- **PLL** phase-locked loop.
- **PPM** pulse-position modulation.
- **PRF** pulse repetition frequency.
- **PSD** power spectral density.
- **RFIC** radio-frequency integrated circuit.
- SFCW Stepped-Frequency Continuous-Wave.
- **SNR** signal-to-noise ratio.
- ${\bf SRF}$ self-resonant frequency.
- ${\bf TF}$ transformer.

UWB Ultra-wideband.

 $\mathbf{VNA}\xspace$ Vector Network Analyzer.

 $\mathbf{VSWR}\,$ voltage standing wave ratio.

Chapter 1 Introduction

Currently, medical imaging of the human body is performed at specialized laboratories equipped with extremely sophisticated and expensive imaging instruments. The current practice is that a physician refers a patient for imaging if any health problem is suspected. The complexity of the referral process, scheduling, and possible risks involved in certain imaging methods prevent the frequent screening of the patients for possible health problems that may go unnoticed for a long time. The late detection of health issues, particularly cancer, significantly reduces the chance of treating the disease.

The availability of a medical imaging device that can be readily deployed ondemand in the physician's office is highly beneficial for early diagnosis of diseases, particularly cancer. The desired imaging device should have the following characteristics:

- its frequent use must not introduce any health risks to the patient, physician, and others
- it must be portable and have a small form factor
- the device must be produced at low cost for widespread adoption
- must produce images with acceptable range accuracy
- it must be easy to operate

- does not create any discomfort for the patients
- preferably should be battery-operated not require access to electricity

This dissertation focuses on developing an integrated imaging system that can satisfy all the requirements described above. The proposed imaging system will focus on imaging of the breast for the early detection of breast cancer. Microwave imaging is chosen because it is among the safest imaging modalities, not imposing any health risk if frequently used, as described in Section 1.1. Ultra-wideband radar technology is employed because of its low complexity and low power consumption, as explained in Section 1.3. The imaging system will be integrated in CMOS technology for low implementation cost and small form factor.

1.1 Medical Imaging of Breast Cancer

According to the global cancer statistics 2018, breast cancer is the most commonly diagnosed cancer and the leading cause of cancer death in women worldwide [1]. In 2020, a projected 27,400 females will receive a diagnosis of breast cancer in Canada, accounting for 24.9% of all new cancer cases in women [2]. Attributed to early detection and improved treatment, breast cancer mortality has been decreasing steadily since the 1990s in the US, Canada, and many European countries, and the five-year net survival for breast cancer of over 85% has been reached [3].

Mammography, X-ray imaging of the breast, is the primary screening technique for breast cancer diagnosis. However, mammography involves low-dose ionizing radiation of the tissue that may introduce health risks with frequent testing [4][5]. Especially for young women, the health risk of repeated exposure may outweigh the benefits of regular mammography. The screening results of women in their 40s in [5] revealed a false positive rate of about 12%. Furthermore, mammography is uncomfortable for some women because it requires the breast to be compressed between two plates to achieve the desired tissue uniformity.

The key to every cancer detection technique lies in the existence of a contrast in the properties of healthy and cancerous tissue. For instance, mammography compares the density of the healthy breast and malignant tissues and their corresponding transparency of X-rays. The sharp contrast in electromagnetic properties between healthy and cancerous breast tissues has inspired microwave engineers to work on using non-ionizing electromagnetic waves to image the breast to detect cancer. While the dielectric permittivity of cancerous and healthy tissues of other body organs differ negligibly according to reports, the permittivity of breast tumors is at least three times higher than that of surrounding healthy tissues [6][7][8][9][10]. This sharp contrast in permittivity makes microwave imaging an attractive method to detect breast cancer, with the promise of better sensitivity and higher reliability compared to conventional imaging methods. The main advantage of Microwave Imaging over mammography is the elimination of any health risk because the body is only exposed to low-power non-ionizing microwave signals (usually thousands of times less than cell phone radiation). Therefore, doctors can comfortably prescribe microwave imaging for breast screening to detect cancer at very early stages.

Research over the past decades has demonstrated the achievability of applying microwave imaging in the field of breast cancer detection [11][12][13][14][15]. The system developed in [16][17] has shown great results and is undergoing clinical trials. The system performance, however, is limited by the low level of integration with bulky size and more induced loss. By integrating the major circuitry of the microwave imaging system on a single chip, system miniaturization can extensively improve the reliability and reduce the cost.

An integrated microwave imaging radar system in CMOS technology for breast cancer detection was first proposed in [18]. The presented integrated circuit can directly connect to the antennas to avoid using a complex switching network and an expensive Vector Network Analyzer (VNA) in measurement. The Stepped-Frequency Continuous-Wave (SFCW) approach is employed in the system to sweep the 2-to16-GHz band with a frequency step size of 90 MHz. The oscillator has to precisely generate all the frequencies within the band. The system works in the frequency domain like a narrowband system at each frequency step; the time-domain waveform is then retrieved by performing an inverse Fourier transform (IFFT). The system is able to detect the tumor target with a resolution of 3 mm.

An eight-channel wide-bandwidth 10-MHz electrical impedance tomography (EIT) integrated system is presented in [19] that detects breast cancer by exploiting the electrical characteristics. Wideband operation is needed because the cancer cells have greater impedance changes than the normal cells, as the frequency increases. Small noise level and phase error are important for high accurate detection and to ensure small artifacts in image reconstruction. The system successfully detects a small-size target object of 0.5 cm.

1.2 Ultra-Wideband Technology

The origin of ultra-wideband (UWB) technology can be traced back to the 1960s when non-sinusoidal radio research started to appear in scientific journals [20][21]. Since then, the UWB technique had been actively researched and hundreds of papers have been published. However, it was not until 2002, when the Federal Communications Commission (FCC) established spectrum regulations for unlicensed UWB applications from 3.1 to 10.6 GHz [22] (regulation for indoor environment shown in Fig. 1.1), that rapid growth started to occur in the development of UWB applications such as penetration radar, through-wall imaging, high-data-rate UWB communication, and medical imaging. Another force behind the explosive development of the UWB applications is the availability of low-cost radio-frequency integrated circuit (RFIC) implementations utilizing complementary metal-oxide-semiconductor (CMOS) technology. By integrating the digital, analog, and RF components on a single chip, a UWB wireless system can be designed with low cost and high reliability.

UWB technology is attractive in both wireless communication and radar systems



Frequency (GHz)	PSD (dBm/MHz)
0 - 0.96	-41.3
0.96 - 1.61	-75.3
1.61 - 1.99	-53.3
1.990 - 3.1	-51.3
3.1 - 10.6	-41.3
Above 10.6	-51.3

Figure 1.1: FCC regulation for an indoor environment.



Figure 1.2: Time domain narrowband and UWB signals and the corresponding spectrum in the frequency domain.

due to the superior advantage of large bandwidth. Different from a narrowband signal, which concentrates its energy in a small frequency range, a UWB signal distributes the signal power over a wide spectrum, thus obtaining very low power spectral density (PSD) at each in-band frequency (Fig. 1.2). This leads to a low interference with other existing narrowband radios, even with a considerable amount of total signal power, thus making possible the coexistence of different systems sharing the same operating frequency range. In a wireless communication system, bit-rate performance is another motivation that promotes continuous exploration in the UWB technique. As revealed from Shannon's formula [23]

$$C = B \cdot \log_2(1 + \frac{S}{N}), \tag{1.1}$$

where C is the channel capacity (upper bound on bit rate), B is the channel bandwidth, and S/N is the signal-to-noise ratio (SNR) of the system, higher bit rates can be achieved with either wider signal bandwidth and/or larger signal power. But it is more efficient to increase the channel capacity by increasing the bandwidth since the SNR and bit rate have a logarithmic relationship.

When it comes to radar and imaging systems, UWB technology exploits the benefits of the ultra-wide bandwidth by using ultra-short duration pulses in the time domain, making high spatial resolution possible. The free-space range resolution (resolution along the direction of signal transmission, assuming that the reflected signals do not overlap) of a pulse radar system can be expressed as

$$R = \frac{c \cdot \tau}{2},\tag{1.2}$$

where c is the speed of light (signal transmission speed in free space), and τ is the pulse duration, which is roughly equal to the reciprocal of signal bandwidth. As can be noted from Eq. (1.2), a larger signal bandwidth is preferred for a system aiming for high resolution. As an example, a UWB radar system working within the 3.1-to-10.6 GHz band reaches a range resolution of about 2 cm in free space. Noting that the signal propagation speed is a function of medium permittivity ϵ and permeability μ as

$$c' = \frac{1}{\sqrt{\epsilon \cdot \mu}} = \frac{1}{\sqrt{\epsilon_0 \epsilon_r \cdot \mu_0 \mu_r}} = \frac{c}{\sqrt{\epsilon_r \cdot \mu_r}},\tag{1.3}$$

where ϵ_r and μ_r are the relative permittivity and relative permeability of the medium, generally, a higher range resolution can be obtained for applications applied in non-air environments. Another feature worth mentioning is the signal penetration capability. Although it is feasible to pursue large bandwidth resources toward high center frequencies in the millimeter-wave band, the loss induced by the medium also rises with increasing frequency, which limits the depth of the detection. In addition, the transceiver circuitry at higher frequencies is usually more complex, which increases the cost.

Traditionally, UWB applications have been mostly used in military communication or radar applications and have been designed with lumped or distributed circuits using discrete diodes [24][25] and/or transmission lines [26], which have the drawbacks of bulky size and high loss. RFICs in GaAs or silicon bipolar technology provide a compact and more reliable solution but they are too expensive for the commercial market. Benefiting from the continuously-shrinking channel length of CMOS technology, tremendous improvement has been achieved in the intrinsic speed of MOS transistor (the transit frequency (f_T) of 65-nm CMOS technology now reaches over 200 GHz), which makes it an ideal solution for cost-effective UWB implementations. As CMOS technology is widely used to implement digital parts of wireless systems, it is highly desirable that the radio-frequency circuits can also be designed in the same technology, which enables the development of single-chip solutions. With a higher level of integration, a more compact design can be achieved with enhanced reliability and robustness.

1.3 UWB Medical Imaging

The approaches of microwave breast imaging can generally be divided into two classes depending on the acquirement of transmitted or reflected scattered signals. The first approach is based on tomographic imaging. Similar to X-rays, the magnitude and/or phase of a transmitted microwave signal varies differently when passed through healthy and cancerous tissues. The dielectric profile of the breast can thus be obtained by analyzing the properties of the signal transmitted through the breast (Fig. 1.3). To accurately reconstruct the breast image, the measured analog signals are converted to



Figure 1.3: Microwave imaging by analyzing the signal transmitted through the breast.

digital signals using high-speed analog-to-digital converters (ADCs). The converted signals need to be further processed in the digital domain using high-performance microprocessors (or computers) to extract the signal information. In addition to the digital signal processing, algorithms [27][28][29] are needed to solve the inverse scattering problem, which may greatly increase the demand for computation power.

The second approach is based on radar utilizing reflected signals (Fig. 1.4). The basic underlying procedure is to illuminate the breast with microwaves and then locate the strong scatterers in the breast by measuring the transmitted and reflected microwave signals. Confocal microwave imaging (CMI) [11][12][13][30] is the most prominent approach that utilizes UWB pulses for breast cancer detection. When a wideband signal, condensed in the time domain, traveling within a medium reaches a boundary between two materials with different dielectric constants, some of the signal power will be reflected back to the source with a signal shape similar to the transmit-



Figure 1.4: Microwave imaging by analyzing the signal reflected from the breast.

ted signal. The advantage of using an impulse-like (wideband) signal is that the delay between the transmitted and reflected signals can be simply found by measuring the time delay between the peaks of the signals, their crossings of certain levels, and their cross-correlation. In this method, the time delay between the transmitted signal and the reflected signal at the receiving antenna is measured to determine the distance of the scattering element from the respective antenna, identifying a sphere for the possible location of the tumor. If at least three antennas are used, as shown in Fig. 1.5, the location of the tumor can be found at the intersection of these spheres. This approach avoids computation-demanding signal processing and complex image-reconstruction algorithms by simply identifying the presence and location of significant scattering elements (tumor) in the breast.

In [31], a UWB radar-based breast cancer detection system with CMOS circuits employing confocal algorithm is described. In the UWB signal generator, up-pulses and down-pulses are digitally generated and combined to compose a Gaussian mono-



Figure 1.5: Confocal microwave imaging demonstration.

cycle pulse (GMP) with a center frequency of 6 GHz. Equivalent-time sampling (ETS) is employed in the UWB receiver to sample the received signal at an equivalent rate of 102.4 Giga samples per second (GSPS). A switch matrix is used to control the antenna array. The transmitter module, receiver module, and switch-matrix module are designed separately and connected with off-chip amplifiers and logic devices. The system successfully detected a 1-cm target in the breast phantom.

1.4 Thesis Overview

This thesis aims to develop an inexpensive and accurate breast imaging radar system capable of detecting the presence and location of small malignant breast tissues. Given the promising high resolution of the UWB signal in the radar system and the relatively low complexity of CMI detection, a UWB radar system working in the 3.1-to-10.6-GHz band is proposed. To improve the power consumption and reliability, the system is realized in a standard CMOS process. The imaging radar system includes three major parts: the antenna array design, radar circuitry design, and image-reconstruction algorithm design. In this thesis, we only focus on the second part by investigating the design of a low-cost fully-integrated 3.1-to-10.6-GHz band UWB radar in CMOS technology.



Figure 1.6: Cross-correlation UWB radar system block diagram.



Figure 1.7: Cross-correlation detection demonstration.

The block diagram of the proposed UWB radar system for detecting breast cancer is shown in Fig. 1.6. The radar system uses a cross-correlation receiver topology. In the transmitter part of the system, a pulse generator is used for successive generation of UWB pulses, followed by a transmitting antenna. In the receiver part of the system, a programmable delay generator is used to trigger the local template generator, which produces a delayed replica of the transmitted UWB signal. The delayed replica is first multiplied with the amplified reflected-signal from the breast, then the result is integrated to produce the cross-correlation of the signals. This process is repeated by the programmable delay generator, producing successive delays by sweeping the tissue within the breast. If there is a significant scatterer within the breast, the crosscorrelation of the two signals peaks (Fig. 1.7) at the time delay that corresponds to the distance of the scatterer to the antenna. Since the output of the correlator maximizes when the reflected UWB signal aligns with the local template, the key challenge then is to produce the smallest possible time shift in order to increase the resolution of the imaging system.

In the following chapters, the design and implementation of a fully-integrated UWB radar system in a 65-nm CMOS technology will be presented.

In Chapter 2, the commonly employed methods of UWB pulse generation and detection are introduced. The considerations of selecting the UWB transmitter and receiver structures are also discussed. In Chapter 3, two UWB pulse generator designs capable of producing high-amplitude UWB pulses are described. Chapter 4 presents the design details of each block in the UWB receiver with simulation results. Finally, conclusions and future work are discussed in Chapter 5.

Chapter 2

UWB Transmitter and Receiver Topologies

According to the FCC and the International Telecommunication Union (ITU), UWB is defined as electromagnetic radiation with a bandwidth exceeding the lesser of 500 MHz or 20% of the arithmetic center frequency [32], as depicted in Fig. 2.1. Corresponding to the two different definitions, the design approaches of the UWB system are also divided into two paths.



Figure 2.1: The signal is UWB signal if $f_H - f_L > 0.2 \frac{(f_H + f_L)}{2}$.

The first path slices the 3.1-to-10.6-GHz band into multiple sub-bands, each with a bandwidth of about 500 MHz [33]. The benefit of this path is that the circuit design can make use of the mature narrowband carrier-based design concepts and topologies with an expanded working bandwidth. This approach is only employed in UWB communication systems.

The second path looks from the angle of impulse radio, which exhibits large bandwidth in frequency and short duration in the time domain. Generally, the receiver of impulse radio only needs to detect the existence of the impulse signal. Thus the UWB transceiver system of this path can employ a much simpler circuit topology with low power consumption. This approach is widely employed in UWB radar systems. This project mainly focuses on the second path to implementing a 3.1-to-10.6-GHz impulsebased UWB radar system that features low complexity, low power consumption, and long detection range.

Other than bandwidth, parameters such as pulse amplitude, pulse shape, and power spectral density also contribute to defining a UWB pulse. In this chapter, the methods of generating UWB pulses will be presented, followed by a review of the topology of UWB receivers. The topology choices and considerations of the UWB transmitter and receiver employed in this research are also discussed.

2.1 UWB Pulse Generation Structures

Several methods can be employed to generate UWB pulses. From a time-domain perspective, pulses such as high-order Gaussian pulses [34][35] are popular as its spectrum can satisfy the FCC limitations without extra filters. From a frequencydomain perspective, a UWB signal can be generated by passing a broadband signal through a bandpass filter, which blocks the out-of-band frequency components of the input signal [36]. In the design of UWB radar systems, bandwidth and amplitude are considered the most important parameters. As mentioned in Chapter 1, RFIC design in CMOS technology offers low cost, low-power consumption, and compact form factor. It also enables the development of single-chip solutions integrating RF front-end with the digital part of the system. Generally, the techniques employed for the design of CMOS pulse generators can be grouped in the following categories.

2.1.1 Digitally-Delayed Impulse Combination



Figure 2.2: Digitally-delayed positive- and negative-peak impulse combination.

As CMOS technology is most widely used in digital circuit design, it is feasible to produce UWB signals digitally. As shown in Fig. 2.2, several digitally-generated short pulses can be delayed and combined to create UWB pulses.

Triangular pulses were generated and combined in [37] to compose an envelopesampled raised-cosine pulse to have a similar spectrum distribution. Instead of passing the combined signal through a power amplifier, multiple independent parallel power amplifiers were employed in [38][39] to compose a pulse with Gaussian-shape envelope. [40] proposed impulse generator cells that can be easily controlled with a data signal to get inverse symmetrical pulses for bi-phase modulation (BPM). A digitally-combined wave has good flexibility but lacks the ability to drive the antenna load with high output power, even after power amplification, as the output amplitude is limited by V_{DD} to avoid distortion of the waveform.

2.1.2 Oscillator-Based Pulse Generator

As depicted in Fig. 2.3, an oscillator is capable of generating a narrow-band sinusoidal signal; however, it can be turned into a wideband signal generator if its output signal is modulated with another narrow pulse.

A mixer was used in [41] to up-convert a triangular wave (triangular/trapezoidal wave in [42]) to create a carrier-based UWB pulse. The total power consumption is



Figure 2.3: Oscillator-based pulse generator.

relatively high considering that the oscillator is on all the time. The work presented in [43] and [44] proposed switching on and off the oscillator loop and oscillator current source, respectively, to reduce the power consumption. Two sets of ring oscillators were employed in [45] to realize a burst mode of binary phase-shift keying (BPSK) + pulse-position modulation (PPM). Oscillator-based output wave amplitude is limited by the oscillator start-up speed and the supply voltage (i.e., V_{DD}).

2.1.3 Pulse Derivation

In the digitally-delayed and combining method, each impulse addition will inevitably increase the pulse duration, which corresponds to smaller signal bandwidth. Whereas the pulse duration time will be constant if composing the pulse by taking derivatives of an impulse, as depicted in Fig. 2.4.



Figure 2.4: UWB pulse generation by taking the derivative of the pulse's rising and falling edges.

Fifth- and sixth-order derivative Gaussian pulses were created in [35] using five stages of differentiators composed of RC coupling networks. However, because the highpass filter itself is a voltage divider, amplitude losses are also introduced during each derivative. Although an amplifier was added after each differentiator, it could only work in the triode region to avoid affecting the functionality of the differentiator. Thus this method is not a good candidate for high amplitude design either.

2.1.4 Spectrum Filtering

Considering the spectral regulation of the UWB signal, the output pulse can easily satisfy the FCC mask if a bandpass filter is added before the antenna to filter out the out-band frequency components, as depicted in Fig. 2.5.



Figure 2.5: UWB pulse generation by spectrum filtering.

In [36], a UWB transmitter was proposed based on the impulse response filter method. An on-chip third-order Bessel filter was utilized to shape a combined edge square-wave signal, and a current-mode power amplifier was added before the filter to boost the output pulse amplitude. The use of a power amplifier makes it possible for the output pulse to exceed the supply voltage. However, the third-order filter is still lossy due to the low quality factor of the on-chip inductors and capacitors.

2.2 Consideration of UWB Pulse Generation

Over the 3.1 GHz to 10.6 GHz band, the PSD mask limitation imposed by FCC is -41.3 dBm/MHz. As the limitation is on the effective isotropic radiated power (EIRP), the average radiated power of a UWB pulse generator can be computed as

$$P_{av} = \frac{E_p}{T_r},\tag{2.1}$$

where E_p is the energy of a single pulse, and T_r is the pulse repetition period. Note that the average power of a UWB signal is proportional to the energy of a single pulse and the pulse repetition frequency (PRF), which is equal to $1/T_r$. To utilize the most of the limited link power budget, the generated UWB pulse should achieve the maximum allowed PSD. As the power limitation is on the average signal power, the PSD can be increased with either higher PRF or higher transmitted energy of a single pulse generated at lower PRF. In data transmission designs, a high-datarate UWB transceiver requires a high PRF proportional to the data rate, the energy of each transmitted pulse has to be limited for FCC mask compliance limiting the transmission range. On the contrary, the performance of a low-data-rate (low PRF) UWB system is usually limited by the maximum pulse energy available from the UWB transmitter. A meter-range transmission can be achieved if sufficient output power can be produced by the UWB transmitter.



Figure 2.6: (a) Transmit-receive system, and (b) transmit-reflect-receive system.

For a transmit-receive system, as shown in Fig. 2.6a, to achieve a certain signal-to-

noise ratio at the receiving antenna, the transmitted power has to be increased with the transmission range to compensate for the free-space path loss (FSPL) given as [46]

$$FSPL = \frac{P_t}{P_r} = \frac{1}{G_t G_r} (\frac{4\pi df}{c})^2,$$
 (2.2)

where P_t and P_r are the power delivered to the transmit antenna and received at the receive antenna respectively, G_t and G_r are the directivities of the transmitting and receiving antennas, respectively, d is the signal traveling distance, f is the signal frequency, c is the speed of light. Thus the peak-to-peak voltage (V_{pp}) in a narrowband transceiver has to increase proportionally to the transmission range since $P_t(\propto$ $V_{pp}^2) \propto d^2$. As a UWB signal can be seen as a set of narrow band signals traveling at the same time, the relationship between V_{pp} and d should maintain consistent.

For a transmit-reflect-receive system, as depicted in Fig. 2.6b, the maximum range with a pulsed signal for a certain SNR is

$$d_{max} = \left[\frac{P_t' G_t G_r \lambda^2 \sigma \tau}{(4\pi)^3 k T_s L \cdot SNR}\right]^{\frac{1}{4}},\tag{2.3}$$

where P'_t is the peak transmitted power, λ is the wavelength of the signal center frequency, τ is the duration of the transmitted signal, kT_s denotes the noise power density at the receiving antenna, L is the antenna loss, and σ is the radar cross section, which is defined as the ratio of the power reflected back to the receiving antenna to the power density incident on the target.

As can be noted, for both types of systems, the detection range increases with higher output power from the UWB transmitters. From another perspective, the performance of the UWB radar system can be better with the same detection range if the UWB transmitter can produce higher output power.

As CMOS technology advances towards the nano-scale, pursuing higher transit frequencies and lower power consumption in the digital circuit by reducing the supply voltage, UWB pulse generator designs with high output amplitude become more
challenging. Although power amplifiers or buffer stages are usually employed in the UWB transmitter to enhance the ability to drive the load antenna, the transmitted power is still limited by the low supply voltage (1 V or less in the advanced CMOS processes) in most cases. Of all the five methods mentioned in the previous section, the spectrum-filtering method is promising in high amplitude design, however, the required high-order bandpass filter is lossy and hard to implement.

In the next chapter, two high-voltage UWB pulse generator designs capable of producing UWB pulses with V_{pp} beyond the supply voltage will be described. In the first design, we present a high-amplitude UWB pulse generator with low complexity by shifting the majority of the pulse shaping effort to the digital domain using trapezoidal waves. The second design introduces an alternative method to produce high-amplitude UWB signals using wideband passive amplification.

2.3 UWB Receiver Structures

Various methods can be employed to detect or revive a UWB signal in the time domain. Depending on the environment of the application, the receiver can be designed to detect the existence of the UWB signal by peak-amplitude or energy detection, or to reproduce the UWB pulse with both amplitude and phase information. In this section, five common methods of detecting a UWB pulse are presented.

2.3.1 Energy Envelope Detection



Figure 2.7: Energy detection block diagram.

As shown in Fig. 2.7, energy envelope detectors can be used to detect the presence of a UWB signal. After a bandpass filter for channel selection, the received signal is first squared by a squarer, which is usually implemented by a diode or a MOSFET working in the saturation region. The signal energy can then be collected with an integrator. Finally, the decision is made by comparing the signal after the integrator with a reference voltage. Although the circuit structure is simple to implement, this type of pulse detection has very limited performance since it detects all the in-band energy irrespective of the pulse type or shape. Any signal with sufficient energy can create a false alarm at the output. This makes this type of pulse detector unfeasible, especially for a low-power UWB signal case where the transmitted pulse coexists with other licensed and unlicensed narrowband/wideband signals.

2.3.2 Cross-Correlation Detection



Figure 2.8: Cross-correlation receiver block diagram.

Fig. 2.8 depicts the block diagram of a cross-correlation receiver. As can be seen, the major difference between an energy detection receiver and a cross-correlation receiver is that a multiplier with a template generator is employed instead of the squarer. The core cross-correlation receiver consists of a template signal generator, a multiplier, and an integrator. Instead of taking the square, the received signal is first multiplied with the generated template signal, which has the same waveform as the transmitted signal, and then fed to an integrator. The output level of the correlator (integrator) depends on how well the received signal matches with the generated template in both time and shape. Thus for optimum detection performance, the template signal has to have the same shape as the received signal and be shifted with a small precise time step.

Since an optimum output only happens when the received signal has the same shape (same spectral properties, in another perspective) as the local template signal, the correlator actually acts like a signal filter. It thus can be expected that the receiver will be more robust to noise and other in-band interference signals. In practice, the receiver performance can be slightly degraded due to the uncertainty of the received signal shape, which can be changed by factors such as frequency-based channel loss and antenna transfer function.

2.3.3 Auto-Correlation Detection

Following a similar principle, the block diagram of an auto-correlation receiver is depicted in Fig. 2.9a. Instead of multiplying the received signal with a locally generated template signal, the received signal is multiplied with a delayed version of "itself". Thus the shape difference of the two multiplying signals is minimized. Compared with the cross-correlation receiver, the auto-correlation receiver has a simpler detection structure without the need of a local template generator. Generally, the auto-correlation receiver is less immune to channel interference with the exception of under a low-SNR system [47], where the received signal suffers significant shape distortion.

As can be seen from Fig. 2.9b, the second UWB pulse (path1) of the two-consecutive pulses received from the antenna is multiplied with the delayed version of the first pulse (path2). Thus a maximum output occurs when the delay t_d produced at the receiver is equal to the time gap between the two UWB signals. Unlike a narrowband scenario, where a delay can be easily implemented with the RC delay circuit, a



Figure 2.9: (a) Auto-correlation receiver block diagram, and (b) time domain signals of path1 and path2.

transmission line will be needed to provide equal delays for all in-band frequencies. As a rough estimation, a delay of 1 ns would require a 30-cm transmission line, which makes it impractical for on-chip implementation. In addition, two-consecutive UWB pulses in one transmission will limit the maximum power of each UWB pulse to be half of the FCC limitation, which results in a smaller detection range. In [48], a combination of an ADC and a digital-to-analog converter (DAC) was proposed to delay and reconstruct the first pulse. However, it is only applicable when the radar system works at relatively low frequencies. Moreover, the circuit consumes more power with added complexity.



Figure 2.10: (a) Direct sampling detection, and (b) time domain signals.

2.3.4 Direct Sampling Detection

Other than detecting the presence of a UWB signal by sensing its energy, a receiver can also detect a UWB signal with digital signal processing. With an ADC to directly sample the UWB signal, the receiver can reproduce the UWB signal with both the phase and amplitude information, as shown in Fig. 2.10.

However, to directly digitize a UWB signal and preserve the signal information at the same time, the sampling frequency $(1/T_s)$ of the ADC has to be as least two times the highest in-band frequency, according to the Nyquist–Shannon sampling theorem [49]. Considering a UWB signal occupying the full 3.1-to-10.6-GHz bandwidth, the sampling rate of ADC has to be at least 21.2 GSPS. Building an ADC with such a high sampling frequency is both difficult and power-hungry.



2.3.5 Sub-Sampling Detection

Figure 2.11: Sub-sampling detection technique.

For a periodic signal with a short duration and a low pulse repetition frequency, sub-sampling or equivalent-time sampling technique can be employed to reproduce a fast transient signal on a large time scale with a frequency much lower than the required Nyquist frequency. As shown in Fig. 2.11, with a sampling frequency slightly larger than the pulse repetition frequency $(1/T_r)$ of the transmitted signal, the sampling circuit of the receiver will sample a different point of the received signal within each sampling period. Since the received signal has the same shape, the samples obtained with this method will be same as the ones obtained if the UWB signal was sampled with a sampling frequency equaling to $1/(T_s - T_r)$. Correspondingly, the resulting sampled signal is expanded to have a duration of $T_s \cdot T_w/(T_s - T_r)$.

Note that the frequency difference of the sampling frequency has to be very close to the pulse repetition frequency. For example, for a T_r of 30 ns (33.3333 MHz PRF), the sampling frequency has to be 33.3111 MHz (T_s of 33.02 ns) to achieve an equivalent sampling period of 20 ps. To generate two high-quality signals with such a close frequency in the presence of noise and temperature variances from a reference is quite challenging.

2.4 Consideration of UWB Signal Detection

As discussed in Section 2.2, other than the bandwidth, the complexity and output power are two main focuses in the design of UWB transmitters. Of all the receiver structures presented in Section 2.3, energy detection is susceptible to in-band interference, the auto-correlation method is not practical because the on-chip transmission line occupies a significant silicon area, direct sampling is also not practical as the in-band frequency is up to 10.6 GHz. Thus cross-correlation and sub-sampling detection methods are the two promising approaches for signal detection for the proposed UWB radar system. For receiver systems employing ADCs, the accuracy of detecting malignant tissues is limited by the speed of the ADCs required to convert the reflected signals from the analog domain to the digital domain. Although the sub-sampling approach can equivalently provide a high sampling rate with low-speed ADCs, the ADCs are still needed to be designed with high resolution to accurately reconstruct the received waveform. The implementation is usually much more complicated compared with cross-correlation detection.

Chapter 3 UWB Transmitters

3.1 A High-Amplitude UWB Pulse Generator with Spectrum Controlled by Digital Synthesis

We present a high-amplitude UWB pulse generator with low complexity by shifting majority of the pulse shaping effort to the digital domain using trapezoidal waves that can be implemented easily using delay cells and logic gates. The synthesized signal is capable of driving the 50- Ω load after being passed through a power amplifier, which boosts the signal amplitude beyond the supply voltage.

To understand the synthesis technique, the spectrum characteristic of a digitally synthesized UWB waveform is analyzed first in Section 3.1.1, and then a new UWB pulse generator with simplified output network design is discussed in Section 3.1.2. The final circuit implementation is presented in Section 3.1.3. Section 3.1.4 demonstrates the measurement results in a standard 65-nm CMOS technology and compares the performance with other reported UWB pulse generators.

3.1.1 Digital Synthesis of the Input UWB Pulse

As shown in Fig. 3.1a, the time-domain and Laplace transform of a normalized step signal with finite rise time τ_r are [50]

$$V(t) = \frac{1}{\tau_r} t \cdot u(t) - \frac{1}{\tau_r} (t - \tau_r) \cdot u(t - \tau_r)$$
(3.1)



Figure 3.1: Time-domain signal and normalized spectrum. (a) A step signal, (b) single trapezoidal wave, and (c) two consecutive trapezoidal waves.

and

$$V(s) = \frac{1}{\tau_r s^2} (1 - e^{-s\tau_r}), \qquad (3.2)$$

where u(t) is the unit step function. The amplitude of V(s) equals zero at frequencies $\omega = 2\pi N/\tau_r$ (where N is an integer), which means that notches appear periodically in the spectrum of the step signal at frequencies that are related to τ_r . For example, the notches created in the spectrum by setting $\tau_r = 30$ ps are drawn in Fig. 3.1a. Note that the step signal is kept high for a relatively long duration (e.g., 100 ns) after the rising edge, and the spectrum is obtained after removing the DC component using a 50-MHz highpass filter.

Noting that the locations of the notches in the spectrum can be controlled by τ_r , this raises the possibility of eliminating the use of a high-order filter by setting the notch frequencies at the start and end frequency point of the passband spectrum. So it is worth analyzing the relationship between pulse shape parameters (i.e., rise/fall time, duration time) and the spectral characteristic of a finite-slope square pulse (i.e., trapezoidal pulse), which can be easily generated using digital CMOS circuit. Previous research work treats the generated edge-combining pulse as a perfect square pulse [36][43], which is a reasonable assumption when the pulse width τ_w is much larger than τ_r (τ_f). However, in order to satisfy the ultra-wide bandwidth requirement, the total pulse duration usually has to be at the sub-nano second level, in which cases, τ_w will be close to or even smaller than τ_r (τ_f). Therefore, a trapezoidal wave is a more accurate description of the signal for theoretical analysis. Fig. 3.1b shows the normalized time-domain signal of an ideal trapezoidal wave. Assuming that τ_r and τ_f have the same value for simplicity, the time-domain signal equation and its Laplace Transform can be written as

$$V(t) = \frac{1}{\tau_r} t \cdot u(t) - \frac{1}{\tau_r} (t - \tau_r) \cdot u(t - \tau_r) - \frac{1}{\tau_r} (t - \tau_r - \tau_w) \cdot u(t - \tau_r - \tau_w) + \frac{1}{\tau_r} (t - 2\tau_r - \tau_w) \cdot u(t - 2\tau_r - \tau_w)$$
(3.3)

and

$$V(s) = \frac{1}{\tau_r s^2} (1 - e^{-s\tau_r}) [1 - e^{-s(\tau_r + \tau_w)}].$$
(3.4)

The terms $e^{-s\tau_r}$ and $e^{-s(\tau_r+\tau_w)}$ lead Eq. (3.4) to zeros at frequencies $\omega = 2\pi N/\tau_r$ and $2\pi N/(\tau_r+\tau_w)$ (N is an integer). Compared to the step signal, the zeros are determined by both τ_r and τ_w instead of only τ_r . However, it is not possible to set the first two notches at around 3.1 GHz and 10.6 GHz due to its periodicity. For example, if $1/(\tau_r + \tau_w)$ is set to be 3.1 GHz, then $(\tau_r + \tau_w)$ would be equal to 322 ps, however, the following notches generated will appear at 6.2 GHz and 9.3 GHz for N = 2 and 3, respectively. The normalized spectrum for a τ_r of 122 ps and τ_w of 200 ps, as an example, is shown in Fig. 3.1b. Up to 20 GHz, the notches created by τ_r are only at 8.2 GHz and 16.4 GHz. To locate two notch frequencies at 3.1 GHz and 10.6 GHz or nearby, another trapezoidal wave with the same parameters is added to include the pulse gap time, τ_d , as another variable to the design as depicted in Fig. 3.1c. Similarly, the notch frequencies created by two consecutive trapezoidal waves can be calculated as $2\pi N/\tau_r$, $2\pi N/(\tau_r + \tau_w)$ and $(2\pi N + \pi)/(2\tau_r + \tau_w + \tau_d)$.

With a transit frequency of over 200 GHz, it is feasible to implement a 30-ps rising and falling edge trapezoidal wave in 65-nm CMOS technology. If we set $\tau_r = \tau_f =$ 30 ps, $\tau_w = 35$ ps ,and $\tau_d = 20$ ps, notch frequencies calculated for $N \leq 3$ are listed in Table 3.1 with the corresponding spectrum simulation results plotted in Fig. 3.1c. Note that the simulation results agree well with the calculation results. Also note that, although it is possible to set the first and second notch frequency at 3.5 GHz and 10.5 GHz, respectively (by setting $(2\tau_r + \tau_w + \tau_d) = 143$ ps), locating a -10-dB cutoff frequency at 10.6 GHz requires designing a waveform with a notch frequency higher than 10.6 GHz. If the second notch is created at 13 GHz, the first notch will appear at 4.3 GHz, according to Table 3.1.

	N = 0	N = 1	N = 2	N = 3
$\frac{N}{\tau_r}$	N/A	33.3 GHz	$66.7~\mathrm{GHz}$	$100~\mathrm{GHz}$
$\frac{N}{(\tau_r + \tau_w)}$	N/A	$15.38~\mathrm{GHz}$	30.77 GHz	46.15 GHz
$\frac{(N+0.5)}{(2\tau_r+\tau_w+\tau_d)}$	4.35 GHz	13.04 GHz	21.74 GHz	30.43 GHz

Table 3.1: Zeros created in the wave spectrum for N = 0, 1, 2, 3.

The reader may argue that a single trapezoidal wave could also be designed to create the first notch at the upper cutoff frequency, but the magnitude of the spectrum



Figure 3.2: PSD of two trapezoidal waves and a single trapezoidal wave (50 ns repetition period).



Figure 3.3: Two consecutive trapezoidal waves with varying τ_r . (a) Time-domain signal, and (b) normalized spectrum.

within the UWB band is much smaller than that of the two trapezoidal waves resulting in much lower output power, as shown in Fig. 3.2. Furthermore, even if the notch is set at 3.1 GHz, a highpass filter is still needed to filter out the spectrum below 3.1 GHz, in other words, the first notch still simplifies the output filter design.

Although the first two notches in the spectrum are controlled only by $(2\tau_r + \tau_w + \tau_d)$ (see Table 3.1), it is still important to set τ_r to a proper value. One can see in Fig. 3.3 that when varying τ_r from 40 ps to 10 ps, the first notch created by $(\tau_r + \tau_w)$ will move toward a lower frequency and even become lower than the second notch created by $(2\tau_r + \tau_w + \tau_d)$, which reduces the signal bandwidth. However, the first $(\tau_r + \tau_w)$ notch can also benefit the design when τ_r is 30 to 40 ps: the notch will suppress the out-of-band spectrum amplitude between 15 GHz and 20 GHz, as shown in Fig. 3.3b.

In the next section, it will be proved that the spectral characteristics of the two trapezoidal waves can be preserved after passing them through a nonlinear power amplifier.

3.1.2 Trapezoidal-Wave-Driven Power Amplifier Circuit Analysis

As the digital circuit producing the described trapezoidal waveform cannot directly drive a 50- Ω load, it is necessary to boost the amplitude by adding a power am-



Figure 3.4: (a) Trapezoidal wave driven circuit, and (b) equivalent circuit.

plifier in between the signal generator and the load. As it is important to preserve the spectral characteristics of the generated trapezoidal waveform, it is necessary to investigate what the output current shape of a MOSFET would look like if driven by this waveform in order to find the spectral correspondence between the input and the output signals.

Fig. 3.4a shows a simple power amplifier stage. M_1 is driven by a trapezoidal voltage source with the same parameters as the example in the previous section. L_1 and C_1 are set to be 1 μ H and 1 μ F to block the AC signal from the power supply and bypass the DC to the load respectively. R_{load} is set to be 50 Ω . The input waveform $V_{GS}(t)$, drain-source voltage $V_{DS}(t)$, and drain-source current $I_{DS}(t)$ are depicted in Fig. 3.5a. From 0 to t_1 , before $V_{GS}(t)$ reaches the threshold voltage V_{th} , M_1 is in the cutoff region and $I_{DS}(t)$ equals to 0. From t_1 to t_2 , $V_{GS}(t) - V_{th} \leq V_{DS}(t)$, M_1 operates in the saturation region and $I_{DS}(t)$ can be written as

$$I_{DS}(t) = \frac{1}{2}k'\frac{W}{L}[V_{GS}(t) - V_{th}]^2, \qquad (3.5)$$

where W and L are the width and length of M_1 , k' equals to $\mu_n C_{ox}$.

As the load inductor L_1 can be seen as an open circuit and capacitor C_1 can be seen as a short circuit over the frequency band of interest, the equivalent circuit model is shown in Fig. 3.4b. Although the BSIM4 MOS model was used in the simulation, a simplified model is shown here for two reasons. The amplifier works mostly as a switch in large signal mode, but a current source rather than a switch is more appropriate to represent the relationship between $I_{DS}(t)$ and $V_{GS}(t)$. The parasitic capacitors will slow down the rise/fall time of the trapezoidal wave, but they will be ignored at this stage for simplicity. Since all the current comes from the load resistor R_{load} , $I_{DS}(t)$ can also be expressed as

$$I_{DS}(t) = I_{R_{load}}(t) \approx \frac{V_{DD} - V_{DS}(t)}{R_{load}}.$$
(3.6)

Hence, we can conclude from Eqs. (3.5) and (3.6) that from t_1 to t_2 , $I_{DS}(t) \propto$



Figure 3.5: $V_{GS}(t)$, $V_{DS}(t)$ and $I_{DS}(t)$ for $L_1=1\mu$ H. (a) Time-domain signal, and (b) normalized spectrum.

 $-V_{DS}(t) \propto [V_{GS}(t) - V_{th}]^2$. In fact, since $V_{DS}(t)$ drops as $V_{GS}(t)$ rises, a much more linear relationship between $I_{DS}(t)$ and $V_{GS}(t)$ can be observed from Fig. 3.5a due to MOSFET channel length modulation.

After t_2 , where V_{GS} - $V_{th} = V_{DS}$, M_1 goes from the saturation region into the triode region. So $I_{DS}(t)$ can then be written as

$$I_{DS}(t) = k' \frac{W}{L} [V_{GS}(t) - V_{th}] V_{DS}(t).$$
(3.7)

As M_1 can only draw current from R_{load} , $I_{DS}(t)$ reaches its maximum during the transition between the two regions. Due to the opposite trends of $V_{DS}(t)$ and $V_{GS}(t)$, $I_{DS}(t)$ represents a much slower slope from t_2 to t'_2 and t'_3 to t_3 according to Eq. (3.7). From t'_2 to t'_3 , $V_{GS}(t)$ reaches its maximum (i.e., V_{DD}) and $V_{DS}(t)$ remains at its minimum $V_{DS,min}(\approx 0V)$. $I_{DS,max}$ can be derived from Eq. (3.6) as $(V_{DD}-V_{DS,min})/R_{load} \approx 20 \text{ mA}.$

At t_3 , M_1 goes back to the saturation region again and cuts off immediately after as $V_{GS}(t)$ decreases (the subthreshold region is ignored here for simplicity). According to Eqs. (3.5) and (3.6), the trans-characteristic of this stage is the same as that of t_1 to t_2 . The same response would be expected during the second trapezoidal wave.

The analysis above indicates that each trapezoidal wave of $-V_{DS}(t)$ or $I_{DS}(t)$ can be seen as a narrower but sharper version of $V_{GS}(t)$ (shorter τ_r because no current will flow through M_1 before $V_{GS}(t)$ reaches V_{th} , and longer τ_w due to the slower slope when M_1 is in triode region), while the total delay time between the two trapezoidal waves remains constant. Hence, the notches determined by τ_r will be shifted to higher frequencies while the ones created by $(2\tau_r + \tau_w + \tau_d)$ remain the same. As mentioned earlier, the first two notches in the spectrum are both determined by $(2\tau_r + \tau_w + \tau_d)$, thus the changes of the notch positions are of less interest. The Fourier transforms of $V_{DS}(t)$ and $I_{DS}(t)$ are shown in Fig. 3.5b to confirm the above analysis. The spectrum of $V_{GS}(t)$ is also shown for comparison purposes.

One concern in a practical design is that a large inductor (e.g., 100 nH) cannot be effectively implemented on chip as it exhibits a very low quality factor and low self-resonant frequency (SRF), beyond which it will behave as a capacitor rather than an inductor. The time-domain signals and corresponding spectrum with a more



Figure 3.6: $V_{GS}(t)$, $V_{DS}(t)$ and $I_{DS}(t)$ for $L_1=1.5$ nH. (a) Time-domain signal, and (b) normalized spectrum.

practical value of 1.5 nH load are shown in Fig. 3.6. Compared to Fig. 3.5, two major differences can be observed: the first one is between t_2 and t_3 , where there is a linear

increase for $I_{DS}(t)$; the second difference is that there is an obvious above- V_{DD} value for $V_{DS}(t)$ and an exponential drop after that. As the value of L_1 is set to be 1.5 nH, its current no longer remains constant and constitutes a portion of $I_{DS}(t)$ according to Kirchhoff's current law (KCL) as

$$I_{DS}(t) = I_{R_{load}}(t) + I_L(t).$$
(3.8)

From t_2 to t'_3 , the current drawn from R_{load} is still $I_{DS,max}$ while the current from L_1 can be expressed as

$$I_L(t) = \frac{1}{L_1} \int (V_{DD} - V_{DS,min}) dt \approx \frac{V_{DD}}{L_1} t, \qquad (3.9)$$

which explains the linear rise of $I_{DS}(t)$ if substituted in Eq. (3.8).

With inductor current flowing through M_1 , $V_{DS}(t)$ increases even faster after t_3 compared with Fig. 3.5. At t_4 , $V_{DS}(t)$ equals to V_{DD} , $I_{R_{load}}(t)$ drops to zero while $I_L(t)$ reaches its maximum.

From t_4 to t_5 where $I_{DS}(t)$ drops to zero, as $I_L(t)$ drops much slower than $I_{DS}(t)$, part of the current flows through R_{load} pushing $V_{DS}(t)$ over V_{DD} , which explains the above- V_{DD} peak. During this stage, the trans-characteristic is also linear and can be proved as follows.

From t_3 to t_5 , M_1 operates in the saturation region (the subthreshold region is ignored here for simplicity). Applying KCL at the drain node of M_1 and substituting all the current equations, for t_3 to t_5 we can get

$$\frac{k'}{2}\frac{W}{L}[V_{GS}(t) - V_{th}]^2 = \int \frac{-V_{DD} + V_{DS}(t)}{L_1} dt + I_0 + \frac{V_{DD} - V_{DS}(t)}{R_{load}}, \quad (3.10)$$

where I_0 is the initial inductor current at t_3 . Taking the derivative on both sides of Eq. (3.10) and substituting $V_{GS}(t) = -(1/\tau_r)t + C$ (C is a constant), we obtain

$$\frac{k'}{\tau_r^2} \frac{W}{L} t - \frac{k'}{\tau_r} \frac{W}{L} (C - V_{th}) = \frac{V_{DS}(t)}{L_1} - \frac{V'_{DS}(t)}{R_{load}} - \frac{V_{DD}}{L_1}.$$
(3.11)



Figure 3.7: (a) Equivalent RLC circuit, and (b) damping with varying L_1 .

Based on Eq. (3.11), we can conclude that $V_{DS}(t)$ is changing linearly with t $(V_{DS}(t) \propto t \propto -V_{GS}(t))$. Therefore, $V_{DS}(t)$ will increase linearly until M_1 cuts off and reaches its peak at t_5 . After t_5 , all the current from L_1 is fed into R_{load} , and the circuit can be seen as a series RLC circuit with an initial current I_{L,t_5} , as shown in Fig. 3.7a.

According to Kirchhoff's voltage law (KVL) we obtain

$$L_1 \frac{di}{dt} + R_{load} \, i + \frac{1}{C_1} \int i \, dt = 0, \qquad (3.12)$$

where

$$\frac{L_1}{C_1} < \frac{R_{load}^2}{4}.$$
(3.13)

As the circuit is overdamped, current I_{L,t_5} drops exponentially until the second rising edge, which explains the exponential drop of $V_{DS}(t)$. Note from Eq. (3.13) that with a practical value of C_1 , a large inductor will easily give the circuit an underdamped response after M_1 cuts off showing an undesired long tail, i.e., a long pulse time duration. Fig. 3.7b shows the time-domain responses with C_1 of 650 fF and different values of L_1 . As can be seen, the duration time becomes longer with larger inductance values, which is another reason why a large L_1 is not preferred.



Figure 3.8: (a) $I_{DS}(t)$ with varying load inductance, (b) triangular shape $I_{DS}(t)$ assumption, (c) output spectrum with varying load inductance ($\tau_r=30$ ps), and (d) Output spectrum with a 1.5-nH load inductor and varying τ_r .

Although the waveforms of $I_{DS}(t)$ and $V_{DS}(t)$ in Fig. 3.6a look different from $V_{GS}(t)$ compared with Fig. 3.5a, it can be noted that not only is the waveform edge still linear,

the rise/fall time also remains the same. Most importantly, $(2\tau_r + \tau_w + \tau_d)$ remains almost the same, which means the first two notch frequencies will not be affected. Moreover, the above- V_{DD} part of $V_{DS}(t)$ due to a low-load inductance is beneficial for high-amplitude design. The Fourier transform of the signals plotted in Fig. 3.6b also verifies the analysis.

One concern that can be noted from Fig. 3.6b is that the third notch is attenuated with a smaller load inductance. The waveform of $I_{DS}(t)$ with different values of load inductance are depicted in Fig. 3.8a to reveal the cause. As can be seen, although the amplitude and shape of $I_{DS}(t)$ is high and close to an ideal trapezoidal wave when the inductor is small (e.g., 0.1 nH), the output amplitude is low (Fig. 3.8c) since most of the current comes from the inductor instead of R_{load} . As the inductor becomes larger (e.g., 0.5 nH), the rising slope of $I_L(t)$ becomes close to $1/\tau_r$, $I_{DS}(t)$ can be approximated as a triangular wave with a rise time of $(\tau_r + \tau_w)$ and a fall time of τ_r , as shown in Fig. 3.8b. The Laplace Transform of $I_{DS}(t)$ becomes

$$I(s) = \frac{1}{\tau_r^2 s^2} \cdot e^{-s(2\tau_r + \tau_w)} \cdot \underbrace{[\tau_r e^{s(2\tau_r + \tau_w)} - (2\tau_r + \tau_w)e^{s\tau_r} + \tau_r + \tau_w]}_{\text{term1}} \\ \cdot \underbrace{[1 + e^{-s(2\tau_r + \tau_w + \tau_d)}]}_{\text{term2}}.$$
(3.14)

The first notch created by term1 in Eq. (3.14) is at around 200 GHz, thus the notch frequencies created up to 20 GHz are only determined by term2 and can be calculated as $(2\pi N + \pi)/(2\tau_r + \tau_w + \tau_d)$. The notch created by $(\tau_r + \tau_w)$ in the trapezoidal case vanishes when it becomes a triangular wave. $I_{DS}(t)$ turns from a triangular wave into more like a trapezoidal wave as the load inductance increases, and the spectral amplitude in the 13 GHz to 20 GHz band also decreases as expected. Considering the damping, output amplitude and out-of-band notch suppression, a load inductance of 1.5 nH is chosen in the design. As can be seen from Figs. 3.8c and 3.8d, a minimum of 12.8 dB lower amplitude can be achieved with a 1.5 nH load when τ_r varies from 30 ps to 40 ps. To this point, it has been shown that it is possible to control the spectrum notches of the output wave simply by adjusting the time factors of the trapezoidal input signal.

3.1.3 Circuit Implementation and MOSFET Sizing

It is worth mentioning from Table 3.1 that the frequency components from DC to the first notch could not be eliminated no matter what values are set for τ_r , τ_w and τ_d . However, it still allows for the use of a simple highpass or bandstop filter at the output, instead of a complex bandpass filter network, if the zero frequency could be set properly such that the upper -10-dB bandwidth point is positioned at 10.6 GHz through adjusting the trapezoidal wave shape at the input stage.

To achieve minimum loss, an LC circuit that resonates at 1.7 GHz is added after C_1 in parallel across the signal line as a bandstop filter to suppress the low frequency components, as shown in Fig. 3.9a. The digital synthesized trapezoidal wave is generated simply by combining a rising and falling edge through a NOR gate. Two sets of identical trapezoidal waves are created by two branches with different delays. MOS varactors have been added to adjust the capacitance between the two stages of inverters to get proper values of τ_d through V_{ctrl_1} and τ_w through V_{ctrl_2} , respectively. Buffers are designed with gradually increased sizes to provide the driving capability for M_{2a} and M_{2b} and achieve a τ_r about 35 ps. C_1 is set to be 650 fF in the actual design to filter out the DC and part of the low frequency components. The simulation result for the loss of the network composed of L_1 , C_1 , L_2 and C_2 is shown in Fig. 3.9b, the loss is less than 1 dB at frequencies from 4.5 GHz to 10.6 GHz to achieve a high output amplitude. Fig. 3.9c shows the signal flow of the proposed circuit.

Finally, to obtain a high output voltage while maintaining high efficiency, setting the MOSFET size properly is critical. On one hand, the MOSFET has to be large enough to be capable of conducting enough current when it is on. On the other hand, the MOSFET can not be too large as the large parasitic capacitance will increase the







Figure 3.10: $I_{DS}(t)$ with different MOSFET widths.

rise time of the signal and power consumption (the buffer size will need to be increased accordingly). Note that the maximum I_{DS} is actually limited by the inductor current, so a large MOSFET is not necessary either. $I_{DS}(t)$ curves are plotted as a function of the MOSFET width in Fig. 3.10. Based on these results, a width of 128 μ m is chosen in the design to reach a compromise between power consumption and output amplitude.

3.1.4 Measurement Results



Figure 3.11: Microphotograph of the fabricated chip.

The proposed pulse generator chip was fabricated using 65-nm CMOS technology



Figure 3.12: On-wafer output measurement setup.

with a supply voltage of 1 V. Fig. 3.11 shows the microphotograph of the fabricated chip, which occupies a die area of 0.34 mm². The output waveform is obtained by on-wafer measurement where the GSG pad is probed using a 40-GHz cascade Z probe connected to a 16-GHz sampling oscilloscope (Tektronix DPO71604C) through a 4-ft StabilityTM Microwave cable, as shown in the setup in Fig. 3.12. The trigger signal was applied off-chip using a PCB-mounted oscillator. The time-domain signal shown in Fig. 3.13 was directly measured with the oscilloscope and the power spectral density was calculated through the embedded FFT function. The measured peak-to-peak amplitude was 1.62 V. The losses of the cable (1.44 dB), connectors (0.4 dB) and probe (0.5 dB) are added to the measurement results to produce the loss-compensated results, and then the peak-to-peak amplitude is calculated to be 2.12 V. The PSD of the pulses obtained through simulation, measurement and measurement with loss compensation, for a pulse repetition frequency of 33.33 MHz, are shown in Fig. 3.14. Two notches are located at 4.3 GHz and 13.2 GHz, which aligns well with analysis. The -10-dB bandwidth is 7.5 GHz with a -8-dB notch at 4.3 GHz.

As can be noted, the output swing exceeds two times the supply voltage, which



Figure 3.13: Time-domain simulation and measurement of the output pulse.



Figure 3.14: Spectrum simulation and measurement of the output pulse.

may raise reliability concerns. In fact, the circuit can sustain a higher voltage in low duty cycle operation since the breakdown field of SiO₂ is a function of test (stress) time [51]. The t_{BD} model from [52] is used here to predict the oxide lifetime, the dependence of breakdown time t_{BD} on oxide field E_{ox} can be expressed as



Figure 3.15: Breakdown time t_{BD} versus oxide voltage V_{ox} for 2.2-nm oxide thickness t_{ox} .

$$t_{BD} = \tau_0 \cdot e^{\left(\frac{B+H}{E_{ox}}\right)},\tag{3.15}$$

where $B \ (\approx 270 \text{ MV cm}^{-1})$ and $H \ (\approx 80 \text{ MV cm}^{-1})$ are material-dependent, τ_0 is set to be 10^{-11} s. With 2.2-nm oxide thickness in 65-nm technology, the relationship between t_{BD} and oxide voltage V_{ox} is plotted in Fig. 3.15. As can be seen, the breakdown time with 2-V V_{ox} is 5.252×10^5 seconds. If roughly approximating 30 ps of each output pulse will reach around 2 V, with 30-ns repetition period, the oxide breakdown time can be estimated as $t = 5.25 \times 10^5 s \times \frac{30n}{30p} = 5.25 \times 10^8 s \approx 16.65$ years. Thus the maximum repetition frequency for a 10-year lifetime can also be calculated to be about 55.5 MHz. Note that the PSD will shift upward with increasing repetition frequency and should not violate the FCC UWB mask.

The average power consumption including digital synthesis circuit is 0.389 mW. Taking a pulse repetition period of 30 ns and a 1-V supply voltage into account, the overall energy consumption E_C for each period is 11.67 pJ. The energy of each transmitted pulse is

$$E_P = \int \frac{V_{OUT}^2(t)}{50} dt = 2.45 \ pJ. \tag{3.16}$$

The energy efficiency, which is defined as the ratio of transmitted pulse energy to total energy consumption, equals

$$\eta = \frac{E_P}{E_C} = \frac{2.45pJ}{11.67pJ} = 21 \%.$$
(3.17)

Table 3.2 shows the performance comparison with the previously reported UWB pulse generators. The proposed pulse generator achieves the highest pulse amplitude to supply voltage ratio of any UWB pulse generator reported in the literature while exhibiting good power efficiency. The results indicate that the proposed UWB pulse generator is suitable for meter-range and low-power radar/communication systems.

Table 3.2: Summary of performance and comparison with previously reported UWB pulse generators.

Ref.	\mathbf{V}_{pp}	\mathbf{V}_{DD}	$\frac{V_{pp}}{V_{DD}}$	CMOS	$\mathbf{E}_{C}^{\diamond}$	$\mathbf{E}_{P}^{\diamond}$	η	Duration	BW	Area
	[V]	[V]	[%]	[nm]	[pJ]	[pJ]	[%]	[ns]	[GHz]	$[mm^2]$
[36]	1.42	1.2	118.3	130	9	_	_	0.46	6.8	0.54 (die)
[37]	1.28	2.2	58.2	180	825	—	_	1.75	1.4	0.4 (die)
[42]	$0.22 \triangledown$	1.2	18.3	130	14.4	_	_	1	4	0.37 (core)
[43]	0.26	1.8	14.4	180	20	_	_	1	2	$0.08 \ (core)$
[44]	0.673	2.1	32	180	27	_	_	0.5	4.5	0.295 (die)
[53]	0.2^{*}	1.8	11.1	180	2.6	—	_	0.3^{*}	5	0.09 (core)
[54]	0.66	1.2	55	90	8.14	0.21	2.6	0.38	7.5	0.25 (die)
This work	2.12	1	212	65	11.67^{\dagger}	2.45	21	0.5	7.5	0.34^{\mp} (die)

° Energy for/of a single pulse, \triangledown Include ~ 3dB interface loss, * Estimate from simulation results figure (100MHz PRF), [†] Not considering off-chip oscillator, [∓] Without on-chip oscillator.

3.2 A High-Voltage UWB Pulse Generator using Passive Amplification in 65-nm CMOS

In this section, we propose an alternative design for producing high-amplitude UWB signals using passive amplification. To resolve the low supply voltage constraint for a high output amplitude/power design, the passive amplification technique has been widely used in narrowband wireless circuits to increase the output amplitude

through impedance transformation produced by the matching network. To apply this technique to the design of UWB pulse generators, the design of a low-loss matching network is highly challenging as it requires matching the load to the highly nonlinear output impedance of the power MOSFET over the entire 3.1-10.6 GHz UWB band. In addition, a portion of UWB pulse energy is produced from the energy stored in the load inductor after the transistor turns off requiring that the matching network also efficiently passes this energy to the load. The working state of the power amplifier is divided into two stages (OFF and ON) and analyzed separately. Seeking to match on both states, a two-section wideband matching network is designed that further boosts the output amplitude, achieving a peak-to-peak amplitude close to three times of the supply voltage.

This section is organized as follows. Section 3.2.1 describes the passive amplification technique and its compromise in the wideband case. Section 3.2.2 discusses input waveform considerations, working states of the power amplifier, matching network design considering both states, and the proposed UWB pulse generator topology. In Section 3.2.3, the experiment results are presented.

3.2.1 Ultra-Wideband Passive Amplification

Because of the low operating and breakdown voltage of the transistors, the passive amplification technique has been used extensively in narrowband transmitter designs to produce the high output voltage swing required for delivering Watt-level power to the antenna. Using an impedance matching network in between the power amplifier



Figure 3.16: Passive amplification demonstration.

and the load, the load impedance is transformed to much smaller values allowing a large output power to be delivered by the power amplifier without stressing the transistors [55]. Assuming perfect matching can be achieved, for maximum power transmission, between the source R_S and load R_L with a lossless passive matching network shown in Fig. 3.16, the voltage amplification ratio can be derived as

$$G = \frac{V_L}{V_S} = \frac{\sqrt{2P_L R_L}}{\sqrt{2P_S R_S}} = \sqrt{\frac{R_L}{R_S}}, \qquad (3.18)$$

where V_L and V_S are the peak voltage amplitude at the load and source, respectively. P_L and P_S are the power delivered to the load and power delivered to the input port of the matching network, respectively. For example, with $R_S = 0.5 \Omega$ and $R_L = 50 \Omega$, a passive voltage gain of 20 dB can be obtained with passive amplification enabling the delivery of a large amount of power with limited voltage swing at the output of the power amplifier.

Compared with a narrowband power amplifier, the design of the matching network for a wideband power amplifier is significantly more complicated. In narrowband amplifiers, S-parameter simulation (in linear case) or Load-Pull test (in nonlinear case) can be used to easily find the optimum load impedance for a maximum power delivery. However, in the wideband case, especially for a low-data-rate switch-mode amplifier, these tools are not compatible as the output impedance is nonlinear (it varies with both time and frequency). Even with one specific matching network that can be designed to provide acceptable matching at a single frequency or around it, the impedance matching network fails to produce the desired matching over the entire band as the impedance varies with frequency unless the complexity of the matching network being increased significantly. Thus it is not possible to find one specific output impedance value and a matching network that can achieve perfect matching for all the in-band frequencies. Apart from that, there exists a theoretical reflection coefficient limit Γ on the matched bandwidth for a parallel RC load impedance [56]

$$\int_0^\infty \ln \frac{1}{|\Gamma(\omega)|} d\omega \le \frac{\pi}{R_L C}, \qquad (3.19)$$

from which it can be concluded that perfect impedance matching is not achievable for a non-zero bandwidth and that out-of-band mismatch also plays a role on the in-band matching performance. Assuming a flat reflection response over the required frequency bandwidth $\Delta \omega$ and $\Gamma(\omega)=1$ for all the out-of-band frequencies, the in-band reflection coefficient $\Gamma_{\Delta\omega}$ can be derived from Eq. (3.19) as

$$\Gamma_{\Delta\omega} = exp(\frac{-\pi}{\Delta\omega R_L C}). \tag{3.20}$$

Then the ideal passive amplification ratio in a wideband case (assuming the same group delay over the frequency band) can be approximated as

$$G_{\Delta\omega} = \frac{\sqrt{2(1 - \Gamma_{\Delta\omega}^2)P_S R_L}}{\sqrt{2P_S R_S}} = \sqrt{\frac{(1 - exp(\frac{-2\pi}{\Delta\omega R_L C}))R_L}{R_S}}.$$
 (3.21)

Note that although the passive amplification ratio $G_{\Delta\omega}$ decreases with increasing bandwidth, the signal will still be amplified when $\Delta\omega < \frac{2\pi}{R_L C \ln(1-R_S/R_L)}$ in the ideal case ($\Gamma_{\Delta\omega} < \sqrt{1 - \frac{R_S}{R_L}}$ in the non-ideal or non-perfect matching case).

In the next section, a high output amplitude UWB pulse generator employing a power amplifier and a wideband matching network is discussed. A passive matching network consisting of a parallel LC load and a two-section matching network is proposed in the design to implement a wideband nonlinear impedance matching. With passive amplification, the peak-to-peak amplitude of the output pulse can exceed 3 times of the supply voltage in simulation.

3.2.2 Proposed UWB Pulse Generator Design Power Amplifier Topology and Input Waveform Parameters

Fig. 3.17 shows the proposed UWB pulse generator topology. It consists of a trapezoidal waveform generator, a driver stage, a switch-mode MOSFET power amplifier, and a passive matching network. As no bias current will be introduced and the voltage



Figure 3.17: UWB pulse generator block diagram.

across the MOSFET will stay low when it is conducting current, the switch amplifier is chosen to achieve both high efficiency and high amplitude.

In general, wideband filtering/impedance matching is designed either with high order or with multiple sections to achieve a steep band slope/low quality factor. Problems accompanied with large number of passive components can be high cost, large size, high complexity, and high loss. Thus the simplicity of the matching network is one of the main concerns in this design.

One way to ease the output network design is to shift the pulse shaping effort to the input waveform design. In [16], two consecutive trapezoidal waves are employed as the input signal to locate the notches of the output spectrum around both the low and high cutoff frequency of the passing band, thus only a simple bandstop filter is needed to the conform its output spectrum to the UWB regulations.

In this work, we utilize passive amplification to enhance the output signal levels through impedance transformation. It is critical that the impedance transformation be achieved by a low-loss matching network capable of matching the nonlinear output impedance of the transistor over the entire band to the greatly extent possible. To reduce the complexity of output matching network, a single trapezoidal wave is used to create a notch at the upper cutoff frequency. The notch locations of one trapezoidal wave can be derived from its Laplace Transform as

$$V(s) = \frac{1}{\tau_r s^2} (1 - e^{-s\tau_r}) [1 - e^{-s(\tau_r + \tau_w)}], \qquad (3.22)$$

where τ_r and τ_w are the trapezoidal wave rise (fall) time and width, respectively. The first notch appears at $\omega = 2\pi/(\tau_r + \tau_w)$, which is obtained by equating Eq. (3.22) to zero and in turn equating $e^{-s(\tau_r + \tau_w)}$ to 1. A single trapezoidal wave with a 40-ps τ_r and a 50-ps τ_w is used in this design. The first notch in its spectrum can be calculated to be 11.1 GHz. This notch is shifted slightly higher in the output spectrum due to the threshold voltage and nonlinearity of the MOSFET which makes $(\tau_r + \tau_w)$ of $I_{DS}(t)$ slightly smaller.

Switch-Mode Power Amplifier Output Impedance

To design a proper wideband matching network at the output of the power amplifier, it is necessary to have an accurate estimation of the output impedance of the power MOSFET. Since the output impedance of the MOSFET changes dramatically within the working period as its input signal variation is large, one way to estimate the effective output impedance is to find an optimum load impedance that maximizes the power transferred from the MOSFET to the load over the entire cycle. With a single trapezoidal wave as the input signal, a simple switch-mode power amplifier with an RF-choke inductor L_0 (100 nH) and a DC-block capacitor C_0 (1 μ F) are used to



Figure 3.18: (a) Pulse generator with RFC and DC block capacitor, (b) OFF and ON state of the circuit.

estimate the optimum load impedance, as shown in Fig. 3.18a. Fig. 3.18b shows the OFF and ON state of the power amplifier. As can be noted, current flows through the load only when the MOSFET is ON and during the transition between the ON and OFF state of the transistor. Note that the later state is ignored here for the simplicity of theoretical analysis. Although the output impedance of the MOSFET can be modeled as a resistor in parallel with a capacitor (accounting for the parasitic capacitors of the MOSFET) when M1 is ON, a purely resistive load R_L is used as the test load for two reasons:

- The reactance of the intrinsic capacitor is usually much larger compared to the ON-resistance of the MOSFET and thus will barely change the total impedance. For example, the reactance of a 200-fF capacitor at 7 GHz is -j113.7 Ω which can be ignored when the resistance of the MOSFET is usually less than 10 Ω , and
- Any added passive component that has a reactance that varies with frequency will make the design of the matching network more complicated.

Under these considerations, the output impedance of the MOSFET is estimated as the same value of R_L , to which a maximum power is transferred during one full ON-and-OFF cycle (same as the power transferred when the MOSFET is ON and during transition).

As the spectral characteristic of the output pulse is controlled by the input trapezoidal wave, it can be expected that the output pulses should have the same shape but different amplitudes with different R_L . When the transistor is ON, the drain-source current $I_{DS}(t)$ can be written as

$$I_{DS}(t) = I_{L_0}(t) + I_{R_L}(t)$$

= $\frac{1}{L_0} \int (V_{DD} - V_{DS}(t)) dt + \frac{V_{DD} - V_{DS}(t)}{R_L} exp(-\frac{t}{\tau}),$ (3.23)

where $\tau = R_L C_0$. Since $L_0 (\to \infty)$ serves as a RF-choke inductor and $C_0 (\to \infty)$



Figure 3.19: (a) $V_{DS}(t)$ with varying load resistance R_L (width of MOSFET is 320 μ m), (b) normalized spectrum of V_{R_L} , (c) single pulse energy E_1 , and (d) single pulse energy located from 3.1 to 10.6 GHz E_2 .

serves as a DC-block capacitor, $1/L_0 \approx 0$ and $\tau \approx \infty$. Eq. (3.23) can be simplified as

$$I_{DS}(t) = I_{R_L}(t) = \frac{V_{DD} - V_{DS}(t)}{R_L}.$$
(3.24)

With different load impedances, the MOSFET can work in either the saturation or linear regions. With the realistic NMOS model from the process design kit (PDK), the $V_{DS}(t)$ of M_1 (320 μm width) with varying R_L is shown as an example in Fig. 3.19a. When R_L is small (e.g. 1 Ω), M_1 can withdraw current to its capability working in saturation region. However, when R_L is large (e.g., 16 Ω), the current is limited by R_L , which will force M_1 to work in the triode region. Taking the triode region as an example, $I_{DS}(t)$ can be expressed as

$$I_{DS}(t) = kV_{DS}(t),$$
 (3.25)

where $k = \mu_n C_{ox} \frac{W}{L} (V_{GS} - V_{TH})$, μ_n is the electron mobility, C_{ox} is the gate oxide capacitance, W and L are the width and length of the MOSFET, and V_{TH} is the threshold voltage.

As $I_{R_L}(t) = I_{DS}(t)$, substituting Eq. (3.25) into Eq. (3.24), the load current I_{R_L} can be expressed as

$$I_{R_L} = \frac{kV_{DD}}{1 + kR_L} \,. \tag{3.26}$$

The output power at the load can be obtained as

$$P_{R_L} = I_{R_L}^2 R_L = \frac{(kV_{DD})^2}{\frac{1}{R_L} + 2k + k^2 R_L},$$
(3.27)

which is maximized as $P_{R_L} = kV_{DD}^2/4$ when the denominator reaches its minimum at $R_L = 1/k$. A similar analysis can be applied when M_1 works in saturation region. Since it is difficult to decide the working region of the MOSFET from just the mathematical equations, the output energy within one period (E_1) corresponding to different load impedances R_L and MOSFET widths are shown in Fig. 3.19c. As can be seen, the optimum R_L for maximum output power delivery becomes smaller as the MOSFET width ($\propto k$) increases. The maximum P_{R_L} is also proportional to kas expected. Taking a 320- μ m MOSFET width as an example, the optimum load impedance R_{opt} should be about 5 Ω to deliver a 7 pJ/period output energy. As shown in Fig. 3.19d, the energy located within 3.1 GHz to 10.6 GHz band also has the same trend which also verifies that, with the same input trapezoidal wave, the output spectral shapes are the same (Fig. 3.19b) with different R_L .

Power Amplifier Load Analysis and Matching Network Design

In practice, an RF choke is bulky in size and lossy because of its large electrical series resistance. Using a finite load inductor, on the other hand, is beneficial as it can be integrated on-chip reducing the overall size and cost of the system. Furthermore, similar with the design of a class-E amplifier, the finite load inductor also serves as


Figure 3.20: (a) Pulse generator with finite inductor and a parallel capacitor, (b) OFF and ON state of the circuit.

part of the matching network, which allows a larger load impedance for the same output power than that for an RF choke [57].

The power amplifier circuit with a finite load inductor is shown in Fig. 3.20a. The load is composed of a finite inductor L_1 and a parallel capacitor C_1 , which represents the sum of intrinsic MOSFET capacitor and external capacitor added to the load network. With C_1 and L_1 resonating at the center of the frequency band of interest, L_1 can be designed in pH level with a high self-resonant frequency, a high quality factor and low loss. Unlike the case with RF choke (Fig. 3.18b), it can be noted from Fig. 3.20b that the finite inductor L_1 continues to conduct current to the 50- Ω load after the MOSFET cuts off. Thus, in addition to matching the 50- Ω load to the optimum load impedance R_{opt} during the MOSFET ON stage, consideration needs to be paid to account for the matching during the OFF stage.

To obtain a matching network with a bandwidth of 7.5 GHz and a center frequency of 6.85 GHz, the quality factor of the matching network can be calculated as Q = 6.85/7.5 = 0.91. To get a more intuitive idea of how to decide on the initial values for components of the matching network, a Smith chart with a characteristic impedance Z_o of 5 Ω as an example is shown in Fig. 3.21. The constant circle of Q equal to 0.9 is drawn corresponding to the quality factor limit of the matching circuit. Since adding



Figure 3.21: Wideband matching in a Smith chart.

inductors and capacitors can be reflected as rotating along the Z or Y circles in the Smith chart, plus the fact that the matching curve from 50 Ω to 5 Ω has to be within the constant Q circle, the ranges for the values of the passive components added in the matching network can be easily decided. To estimate the matching performance, the constant circles of Voltage Standing Wave Ratio (VSWR) equal to 2 and 4 are also shown in Fig. 3.21. As can be seen, without considering L_1 and C_1 and all other design constraints, the best matching performance for a two-section matching network is at node A. Although a better matching performance of VSWR < 2 can be reached in theory at node B with a three-section matching network, the extra losses introduced by the parasitic resistance of the added components can counteract its benefit. Furthermore, with other design constraints that will be discussed later, the matching performance with three-section matching network can be degraded dramatically. A high-order matching network will also significantly increase the complexity of the circuit design. Thus, although the matching is "non-perfect", a two-section matching network seems to be the simplest design that achieves wideband matching



Figure 3.22: Impedance matching when M_1 is ON.

over the 3.1-10.6 GHz band. A bandpass-type two-section matching network is chosen for the design, as shown in Fig. 3.22.

The values of L_1 and C_1 can be first estimated from the following equation

$$\frac{1}{2\pi\sqrt{L_1C_1}} \approx 6.85 \text{ GHz.}$$
 (3.28)

The total input impedance of the matching network (including the load) when the MOSFET is ON can be derived as

$$Z_{IN} = \left(\left(R_L \| j\omega L_3 + \frac{1}{j\omega C_3} \right) \| \frac{1}{j\omega C_2} + j\omega L_2 \right) \| \frac{1}{j\omega C_1} \| j\omega L_1$$

= $R\{L_1, C_1, L_2, C_2, L_3, C_3, \omega\}$
+ $jX\{L_1, C_1, L_2, C_2, L_3, C_3, \omega\}.$ (3.29)

As can be noted, both the real part $\text{Real}(Z_{IN})$ and imaginary part $\text{Imag}(Z_{IN})$ are a function of $L_1, C_1, L_2, C_2, L_3, C_3$ and ω . During this stage, the circuit is well matched if

$$\operatorname{Real}(Z_{IN}) \approx \operatorname{R}_{opt}$$
 and $\operatorname{Imag}(Z_{IN}) \approx 0.$ (3.30)

When the MOSFET is OFF, the output waveform is decided by the natural response of the network. During this stage, the energy stored in L_1 is delivered to the load. From a matching perspective of view, the network should resonate at all the frequencies of interest, which means that the imaginary part of Z'_{IN} , as shown in Fig. 3.23, should cancel the reactance of L_1



Figure 3.23: Impedance matching when M_1 is OFF.



Figure 3.24: Second-order passive network model.

$$\operatorname{Imag}(Z'_{IN}) = \operatorname{Imag}[((R_L \| j\omega L_3 + \frac{1}{j\omega C_3}) \| \frac{1}{j\omega C_2} + j\omega L_2) \| \frac{1}{j\omega C_1}]$$

$$= -j\omega L_1, \quad \text{for } 3.1 \sim 10.6 \text{ GHz.}$$
(3.31)

Under this approximation, the network can be modeled as a second-order passive network with an initial inductor current of I_1 , as shown in Fig. 3.24. To obtain an output waveform with as short a duration as possible, the circuit should be critically damped or over-damped by

$$\frac{Real(Z'_{IN})}{2L_1} \ge \omega, \quad \text{for } 3.1 \sim 10.6 \text{ GHz.}$$
(3.32)

Thus a small load inductor is preferred according to Eq. (3.32). Take L_1 of 250 pH as an example, the Real (Z'_{IN}) needs to be at least 33 Ω to satisfy Eq. (3.32) considering the maximum in-band frequency of 10.6 GHz. Also Z_{IN} can be recalculated by substituting Eq. (3.31) into Eq. (3.29) as

$$Z_{IN} = Z'_{IN} \| j\omega L_1$$

= $[Real(Z'_{IN}) - j\omega L_1] \| j\omega L_1$
= $\frac{\omega^2 L_1^2}{Real(Z'_{IN})} + j\omega L_1$, for 3.1 ~ 10.6 GHz. (3.33)

Then Eq. (3.30) can be rewritten according to Eq. (3.33) as

$$\frac{\omega^2 L_1^2}{Real(Z'_{IN})} \approx \mathcal{R}_{opt} \quad \text{and} \quad j\omega L_1 \approx 0.$$
(3.34)

Note from Eq. (3.34) that although it is possible to tune the Real(Z_{IN}) to be equal to R_{opt} at one or several frequencies, Real(Z_{IN}) still varies since it is a function of frequency. Furthermore, even if a good real-part matching could be achieved for the whole frequency band, the Imag(Z_{IN}), which varies from j4.8 Ω to j16.6 Ω (from 3.1 to 10.6 GHz), can not be set to 0. In another words, Eqs. (3.28), (3.30)~(3.32) and the best achievable matching point A in Fig. 3.21 can not be satisfied simultaneously. The matching performances for when the MOSFET is ON, OFF and the pulse duration have to trade off with one another.

To obtain the values for the six passive components, six equations will be needed for mathematical calculation. This can be done by solving the simultaneous equations composed of Eqs. (3.29) and (3.31) at multiple in-band frequencies. But the pure mathematical solution can be inaccurate because parameters such as the -10 dB cut-off frequencies and characteristics like in-band spectral flatness can not be fully defined by the equations. Also the matching network must be designed such that the output signal spectrum conforms to the FCC mask. A more feasible way is to first start with the initial values of C_2 , L_2 , C_3 , and L_3 from the Smith chart (Fig. 3.21) and initial estimates of L_1 and C_1 from Eq. (3.28), then try to solve the simultaneous equations composed of Eqs. (3.29) and (3.31) with those initial values, and finally adjust the values with Eqs. (3.32) and (3.34) as the optimization goals. With a few iterations, the values of each component can be found. However, the final values should be tuned considering all the constraints and according to both the spectral regulation and time-domain performance.



Figure 3.25: Schematic of the proposed pulse generator.

Circuit Implementation and Performance Simulation

The schematic diagram of the proposed UWB pulse generator circuit is depicted in Fig. 3.25. The trapezoidal wave is generated through a NOR gate which combines a rising and a falling edge with a delay time that is controlled by V_C . A driver stage consisting of six inverters is added after to increase the driving capability. The circuit in this design aims to generate a UWB pulse with a peak-to-peak amplitude of three times the supply voltage, the peak current conducted by the MOSFET must reach hundred-mA levels. Since the maximum current of the circuit is mainly limited by the size of the transistor, a MOSFET width of 320 μ m is chosen for the power amplifier to produce the required current. Thus the optimum impedance R_{opt} should be 5 Ω according to the analysis in Section 3.2.2. With a wideband and non-perfect matching at the drain node of the MOSFET, the voltage amplification ratio will be less than $\sqrt{R_L/R_S}$ as mentioned in Section 3.2.1, and the peak voltage of $V_{DS}(t)$, which appears when the input voltage $V_{GS}(t)$ drops to 0 from V_{DD} , can be more than 2 times of V_{DD} . To enhance the reliability of the design, two cascode MOSFETs with a width of 640 μ m are used. A maximum tolerable DC voltage of 1.2 V, which can be implemented by a DC-DC converter circuit in the future design, is applied to the gate of cascode common-gate MOSFET M_{1b} , as shown in Fig. 3.25. Thus the maximum voltage experienced by the MOSFET can be reduced from V_{DS} to



Figure 3.26: Z_{IN} and Z'_{IN} of the proposed matching network.



Figure 3.27: Butterworth 3rd-order bandpass filter.

 $V_{DS} - 1.2$. Excluding the effect of the parasitics, ideal inductors and capacitors are used in the simulation of this section. The values of the passive components are listed in Table 3.3 and the corresponding values of Z'_{IN} and Z_{IN} are shown in Fig. 3.26. As can be seen, the $\text{Imag}(Z'_{IN})$ matches well with $-j\omega L_1$ from 5 GHz to 8 GHz. Note that imaginary matching is implemented in a smaller bandwidth to fulfill a -10-dB bandwidth from 3.1 GHz to 10.6 GHz. The $\text{Real}(Z'_{IN})$ varies in between 5 to 10 Ω while the $\text{Real}(Z_{IN})$ varies from 8 to 30 Ω .

To further compare the performance of the proposed matching circuit, a 3.1-GHz to 10.6-GHz 3rd-order Butterworth bandpass filter designed from 5 Ω to 50 Ω with the same input and power amplifier circuit is shown in Fig. 3.27. The values of the components in the filter network are also shown in Table 3.3. The time domain



Table 3.3: Component values of the proposed passive network.



Time (ns)

Figure 3.28: Time domain signals with the proposed matching network and the 3rd-order Butterworth bandpass filter.

waveform and normalized spectrum of the output signals are shown in Fig. 3.28 and Fig. 3.29, respectively. As can be seen, with ideal passive components, the output peak-to-peak voltage of the proposed pulse generator is about 4.5 V and the pulse duration is about 500 ps. The peak-to-peak voltage of V_{DS} is about 3.1 V (maximum of 3.2 V and minimum of 0.1 V), thus a voltage gain of 1.45 ($\langle \sqrt{R_L/R_S} = \sqrt{10} \rangle$) is obtained which agrees with the previous discussion. The maximum voltage difference experienced by the cascode MOSFET (M_{1b}) is 2 V instead of 3.2 V, which improves the reliability of the circuit. The output waveform of the pulse generator with the



Figure 3.29: Spectrum of the output signals with the proposed matching network and the 3rd-order Butterworth bandpass filter.

3rd-order Butterworth filter, however, has a lower V_{pp} of 2 V and a much longer duration of more than 10 ns. The normalized spectrum of the output pulse with the proposed matching network fits the normalized FCC Mask well while the output pulse spectrum with the Butterworth filter exhibits peaks at a few frequencies having a much smaller bandwidth because the Butterworth filter fails to account for the "imaginary matching" after the MOSFET cuts off.

Layout Considerations

When replacing the ideal inductors and capacitors with the realistic models from the foundry library, the performance of the circuit will be degraded not only because the existence of the parasitic resistors that lower the quality factor of the components, but also because the capacitance/inductance of the capacitor/inductor changes with frequency due to the parasitic inductors and capacitors. Unlike narrowband circuit design, which only needs to make sure that the passive components are tuned to the desired values at one specific frequency, the variance of the values are best kept small as well in a wideband design. Furthermore, the quality factor of the capacitor can be a concern since it intrinsically decreases as the frequency increases.



Figure 3.30: (a) Layout of the 4×200 -fF capacitor, (b) layout of the 800-fF capacitor, (c) Momentum simulated capacitance of the two capacitors, and (d) Momentum simulated quality factor.

To gain a better understanding of the effects to the characteristic of a MIM capacitor by different capacitor sizes, both the layout models of a 4×200 -fF and a 1×800 -fF MIM capacitor were simulated in ADS momentum as an example to obtain the capacitance and quality factor, as shown in Fig. 3.30. As can be noted that, with the 4-parallel capacitor, not only the variance of the capacitance within the 3.1 GHz to 10.6 GHz band is smaller, the quality factor is also much higher. The parallel structure has four times the metal connection width compared with the single capacitor structure having better reliability when conducting large peak current. Thus capacitors C_1 and C_3 in the circuit are designed with a 4-parallel and a 2-parallel structure for the aforementioned reasons.

3.2.3 Measurement results



Figure 3.31: Chip microphotograph.



Figure 3.32: Measurement setup.

The proposed UWB pulse generator was fabricated in a 65-nm CMOS technology with a nominal supply voltage of 1 V. Fig. 3.31 shows the chip microphotograph. The die area is 1×0.56 mm² including the pads. The time domain waveform was obtained by on-wafer measurement using a 16-GHz Tektronix DPO71604C sampling oscilloscope with a 40-GHz cascade Z probe, as shown in Fig. 3.32. The trigger signal was applied externally using an off-chip 33.3-MHz oscillator for demonstration



Figure 3.33: Time domain waveform measurement.



Figure 3.34: Measured power spectral density results.

purposes. Fig. 3.33 presents the measured waveform of the output pulse with a V_{pp} of 1.9 V and a pulse duration of 500 ps. Considering the losses introduced by the connecting cable, Z probe and connectors of about 2.3 dB, the output peak-to-peak voltage after compensation is about 2.49 V, which is 16% less than the post-layout simulation result of 2.95 V shown in the upper left corner of Fig. 3.33. The PSD of the measured output pulse with a repetition period of 30 ns, obtained by the embedded

FFT function of the oscilloscope, is presented in Fig. 3.34. The PSD of the postlayout simulation result is also shown in Fig. 3.34 for comparison. As can be seen, the measured spectral shape is very similar with the simulation except for that the -10 dB bandwidth of the measurement result shrinks a little from 7.5 GHz to 6.8 GHz due to the deviation on the model accuracy.

With loss compensation, the energy of each transmitted pulse can be calculated to be

$$E_p = \int_0^{30n} \frac{V_{load}^2}{50} dt = 2.96 \text{ pJ.}$$
(3.35)

The average power consumption, including digital synthesis circuit, is 0.577 mW. Considering the repetition frequency of 33.3 MHz, the energy consumption E_C of each pulse is 17.31 pJ/pulse. The energy efficiency which can be calculated by E_P/E_C equals to 17.1 %. Table 3.4 summarizes the performance of the UWB pulse generator and compares it with previously reported works. With moderate power consumption, the proposed UWB pulse generator exhibits high output amplitude with a high peakto-peak amplitude-to-supply-voltage ratio.

Table 3.4 :	Summary	of performance an	nd comparison	with j	previously	reported	UWB
pulse gene	rators.						

Ref.	\mathbf{V}_{pp}	V _{DD}	\mathbf{V}_{pp}/V_{DD}	CMOS	\mathbf{E}_{C}	\mathbf{E}_P/E_C	Duration	BW	Area
	[V]	[V]	[%]	[nm]	[pJ/pulse]	[%]	[ns]	[GHz]	$[mm^2]$
[58]	0.24	1.8	13.3	180	80 ⁺	-	1++	2	0.14^{+++} (core)
[59]	0.26	1.8	14.4	180	20	-	1.5^{\diamond}	2.9	$0.021 \ (core)$
[42]	$0.22 \bigtriangledown$	1.2	18.3	130	14.4	-	1	4	$0.37 \; (core)$
[60]	0.94	1.2	78.3	130	37.9	8.6	2.5	0.9	0.146 (core)
[61]	0.45	1.2	37.5	65	30	-	2*	1.7^{\cup}	0.182 (core)
[41]	0.48	1	48	65	59.7	-	3	7.5**	4^{***} (die)
[62]	0.425	1	42.5	45 (SOI)	10	-	0.6	5	0.385 (die)
This work	2.49	1	249	65	17.31^{+}	17.1	0.5	6.8	0.56^{\mp} (die)

⁺ Unit used is pJ/b, ⁺⁺ estimate from measured time domain signal, ⁺⁺⁺ filter off-chip, $^{\circ}$ estimate from measured result when $V_{ctrl} = 1.8 \text{ V}, ^{\bigtriangledown}$ include $\sim 3dB$ interface loss, ^{*} estimate from measured time domain signal, $^{\cup}$ With three 500-MHz channels, ^{**} With three 900-MHz channels, ^{***} Including receiver circuit and PLL, [†] Not considering off-chip oscillator, [∓] Without on-chip oscillator.

3.3 Conclusion

This chapter presents two new UWB pulse generators focused on high output amplitude. These two circuits employ the spectrum filtering method with inductor-loaded power amplifiers to generate high-power UWB signals.

The first proposed design seeks to migrate the majority of the spectrum shaping effort to the input signal design to simplify the output network, which brings the benefits of lower loss and more compact size. Two consecutive trapezoidal waves are chosen as the input signals since the first two notches of the corresponding spectrum can be successfully set nearby both 3.1 GHz and 10.6 GHz. It is analyzed and verified that the locations of notches are not affected after amplification. Including the load, the output network of the proposed design contains only four passive components. The second proposed design focuses on the output network by replacing the lossy filter network with a wideband matching network. It is found that, in order to successfully achieve passive amplification, the power amplifier needs to be matched both when the MOSFET is ON and OFF. Besides the load inductor and capacitor, a two-section matching network is employed. Both the designs were physically implemented and tested in TSMC 65-nm CMOS technology. The measurement results show that the proposed UWB pulse generators are capable of generating UWB signals with amplitude over two times of the supply voltage.

Chapter 4 UWB Receiver and Radar System

In this chapter, a UWB radar system will be introduced and discussed. As explained in Chapter 2, for the UWB receiver structure, the correlation-based method is attractive because of its high detection performance and low design complexity. The auto-correlation method is impractical for a fully-integrated system design because a transmission line is usually needed to produce the true-time delay, which would occupy a significant silicon area. The cross-correlation method is employed in the proposed UWB receiver design. In the sections next, the structure and sub-circuits of the cross-correlation based 3.1-to-10.6-GHz UWB receiver will be described first, followed by the simulation results of the whole UWB radar system. The UWB radar system is fully implemented in TSMC 65-nm CMOS technology.

4.1 UWB Radar System Structure

The architecture of the proposed UWB radar system is shown in Fig. 4.1. In the receiver, the UWB signal reflected by the detected object (tumor) is first amplified by an ultra-wideband low-noise amplifier (LNA). The signal then goes through a multiplier, which multiplies the amplified signal with a local template signal for signal detection. An integrator follows next and outputs a low-frequency signal off-chip to the oscilloscope for object identification. Since the detection resolution of the UWB radar system is directly related to how small the time step that the template signal can



Figure 4.1: UWB radar system block diagram.

be shifted, a high-resolution delay-locked loop (DLL) is designed to generate multiphase clock signals with accurate stage delays. A multiplexer is added to output one of the clock signals from the DLL to trigger the local template generator. The sweep resolution of the UWB radar system is determined by the minimum step size of the voltage-controlled delay line (VCDL). To maintain a synchronized trigger source for both the UWB transmitter and receiver, the off-chip reference signal source is shared by the transmitter and the receiver. To obtain optimum performance of the UWB radar system, the pulse repetition period of the transmitted signal has to utilize the most of the link margin without exceeding the FCC mask. A frequency divider is added before the UWB pulse generator to convert from the reference frequency to the trigger frequency needed by the transmitter.

4.2 Ultra-Wideband Low-Noise Amplifier



Figure 4.2: N-stage cascaded devices chain.

According to Friis' formula [63], the noise factor of a N-stage cascaded devices (Fig. 4.2) can be calculated as

$$F_{total} = F_1 + \frac{F_2 - 1}{G_1} + \frac{F_3 - 1}{G_1 G_2} + \frac{F_N - 1}{G_1 G_2 \cdots G_{N-1}},$$
(4.1)

where F_n and G_n (n = 1, 2, ..., N) are the noise factor and power gain of the n_{th} stage in the cascaded chain, respectively. The noise factor F of a system can be defined as the input signal-to-noise ratio over that of the output as

$$F = \frac{SNR_i}{SNR_o} = \frac{S_i/N_i}{S_o/N_o} = 1 + \frac{N_{add}}{G \cdot N_i},\tag{4.2}$$

where N_{add} represents the noise introduced by the components inside the system, S_i (S_o) and N_i (N_o) are the signal power and noise power at the input (output) of the system, respectively.

It can be noted from Eq. (4.1) that the total noise factor of the chain is mainly determined by the first stage since the noise factor of the remaining stages are attenuated by the gain of the previous stages.

As the first component interfacing with the antenna in the receiver chain, the LNA is important, especially under the circumstance when the received signal is relatively weak. Besides the requirements of high gain and low noise figure (NF), the LNA designed for a UWB system has to possess wide bandwidth so that the received signal can be amplified with minimum shape distortion in the time domain. Since the f_T of the 65-nm CMOS technology reaches over 200 GHz, resistive-feedback common source (CS) LNA topology is a good candidate with the merits of wide bandwidth, high gain, and compact in size [55]. Here, we analyze the input matching, gain, and noise figure of the resistive-feedback LNA to understand the tradeoffs in the LNA design.



Figure 4.3: (a) First stage of the LNA, and (b) simplified circuit model.

Fig. 4.3a shows the circuit of a resistive-feedback CS LNA circuit, where R_s represents the 50- Ω antenna source impedance, C_{ctrl} is the coupling capacitor, M_{1n} and M_{1p} are the common-source MOSFETs, and R_1 is the feedback resistor. First, for simplicity, we assign

$$R_o = r_{o,M_{1n}} \parallel r_{o,M_{1p}}, \tag{4.3}$$

where $r_{o,M_{1n}}$ and $r_{o,M_{1p}}$ are the output impedance of the M_{1n} and M_{1p} , respectively, and

$$G_m = g_{m,M_{1n}} + g_{m,M_{1p}},\tag{4.4}$$

where $g_{m,M_{1n}}$ and $g_{m,M_{1n}}$ are the transconductance of M_{1n} and M_{1p} , respectively. Assuming $G_m R_1 \gg 1$ and $G_m R_o \gg 1$, the input impedance and gain of the LNA can be derived from the simplified circuit model depicted in Fig. 4.3b as

$$R_{in} = \frac{R_o + R_1}{1 + G_m R_o} \approx \frac{1}{G_m} + \frac{R_1}{G_m R_o},$$
(4.5)

and

$$\frac{V_{out}}{V_{in}} = \frac{V_{out}}{V_x} \cdot \frac{V_x}{V_{in}} = \frac{(1 - G_m R_1) \cdot R_o}{R_1 + R_s + R_o + G_m R_s R_o}.$$
(4.6)

Note that the parasitic capacitors have been neglected for simplicity. Then we let $R_s = R_{in}$ assuming perfect impedance matching, Eq. (4.6) can be rewritten by replacing R_s with R_{in} from Eq. (4.5) as

$$\frac{V_{out}}{V_{in}} = \frac{V_{out}}{V_x} \cdot \frac{V_x}{V_{in}} = \frac{(1 - G_m R_1) \cdot R_o}{2(R_1 + R_o)} \approx -\frac{1}{2(\frac{1}{G_m R_o} + \frac{1}{G_m R_1})}.$$
(4.7)

In terms of the noise performance, the output impedance of the LNA can first be derived from Fig. 4.4b as

$$R_{out} = \frac{(R_s + R_1)R_o}{R_s + R_1 + R_o + G_m R_s R_o} \approx \frac{R_o + R_1 + G_m R_o R_1}{2G_m (R_o + R_1)} \approx \frac{R_o R_1}{2(R_o + R_1)}.$$
 (4.8)

Then the noise contribution of R_1 and $M_{1n,1p}$ can be derived from Fig. 4.4a and Fig. 4.4b, respectively, as

$$\overline{V_{n,out_R_1}^2} = 4kTR_1,\tag{4.9}$$

where k is Boltzmann's constant, T is the absolute temperature, and



(b)

Figure 4.4: Noise contributed by (a) R_1 , and (b) $M_{1n,1p}$.

$$\overline{V_{n,out_MOS}^2} = 4kT\gamma G_m \cdot R_{out}^2 = kT\gamma G_m (\frac{R_o R_1}{R_o + R_1})^2.$$
(4.10)

The noise figure of the LNA can be calculated as

$$NF = 1 + \frac{\overline{V_{n,out_R_1}^2} + \overline{V_{n,out_MOS}^2}}{4kTR_s \cdot (\frac{V_{out}}{V_{in}})^2} = 1 + 4(\frac{1}{G_mR_1} + \frac{1}{G_mR_o}) + \gamma \cdot \frac{R_o}{R_o + R_1}.$$
 (4.11)

It can be noted from Eq. (4.11) that larger G_m and R_1 are preferred to obtain a low noise performance. In practice, the value of R_1 is limited up to a few hundred ohms as the LNA has to match to the 50- Ω antenna from Eq. (4.5). The limitation of R_1 also leads to a limited gain of the LNA from Eq. (4.7). To further increase the gain of the LNA, and to utilize a differential signal for a better performance of the UWB receiver, a three-stage ultra-wideband LNA is proposed, as shown in Fig. 4.5. The first stage employs a resistive-feedback CS amplifier which provides good input impedance matching, low added noise, and moderate gain. An inductor-loaded amplifier is employed as the third stage to enhance the gain at the higher end of the



Figure 4.5: Schematic of the proposed LNA.



Figure 4.6: LNA gain demonstration.

passband. The load inductor is implemented by a 1-to-1 transformer (TF) which converts the single-ended UWB signal to a differential signal with no extra cost. Since it is critical to preserve the time-domain characteristic (waveform) of the received UWB signal in the UWB receiver design, the LNA must have a flat gain over the frequency of interest. A resistor R_L is added in series with the primary winding of the transformer to trade the gain amplitude for gain flatness. Since the LNA outputs differential signals to the gates of the MOSFETs in the multiplier, the center tap of the secondary turn is employed to conveniently provide the required bias voltage.

 C_L and C_s are the bypass capacitors for the primary and secondary windings of the transformer, respectively. As noted in the resistive-feedback LNA analysis, the gain of the amplifier is limited by the upper limit of the feedback resistance due to input matching. To improve the gain flatness of the LNA, another resistive-feedback amplifier is added as the second stage to improve the gain at the lower end of the passband. The gain of each stage is demonstrated in Fig. 4.6. With the feedback resistor, the first two stages are able to be self-biased while the bias of the third stage is provided by the second stage. The PMOS-to-NMOS size ratio is the same for all three stages and is designed such that the bias voltage is about $V_{DD}/2$ to obtain good linearity. To make a more practical implementation, the design of the LNA considers the effect of the GSG pad and bonding wire by adopting the parasitic capacitance (approximately 25 fF) and inductance (approximately 800 pH ~ 1 nH) into the input matching network.



Figure 4.7: Transformer model circuit.

Some considerations in the design of the transformer can be revealed from a simple transformer model circuit, as shown in Fig. 4.7, where L_p and L_s represent, respectively, the self-inductances of the primary and secondary windings of the transformer, M and C_F are the mutual inductance and coupling capacitance between the primary and secondary windings, respectively. Assuming $L_p = L_s = L$ for the 1-to-1 transformer model, the transfer function from V_{in} to V_{out} can be derived as [55]

$$H(s) = \frac{V_{out}}{V_{in}}(s) = \frac{L_p L_s (1 - \frac{M^2}{L_p L_s}) C_F s^2 + M}{L_p L_s (1 - \frac{M^2}{L_p L_s}) C_F s^2 + \frac{L_p L_s}{R_L} (1 - \frac{M^2}{L_p L_s}) s + L_p}.$$
(4.12)

The poles of the transformer circuit are

$$\omega_{p1,2} = \frac{1}{2R_L C_F} \left[-1 \pm \sqrt{1 - \frac{4R_L^2 C_F}{L(1-k^2)}}\right],\tag{4.13}$$

where k is the mutual coupling coefficient (≤ 1), which can be expressed as

$$k = \frac{M}{\sqrt{L_p L_s}} = \frac{M}{L}.$$
(4.14)

In a practical design, the poles from Eq. (4.13) need to be located well above the passband of the system. As can be noted, the pole frequency will be pushed to infinity by either letting k = 1 or $C_F = 0$, which indicates an infinity bandwidth. Thus, k should be made as close to 1 as possible, and C_F , which actually contributes to the degradation of k, should be minimized in the transformer layout.

After neglecting C_F in Fig. 4.7 and assuming $R_s = R_L$, another form of bandwidth expression, the fractional bandwidth (FBW), was derived in [64] as a function of k as

$$FBW = \frac{f_u}{f_l} = \frac{1+k}{1-k},$$
(4.15)

where f_u and f_l are the upper and lower cut-off frequencies, respectively. The equation also indicates that a larger k maps to a wider bandwidth, the upper cut-off frequency of a transformer can be 7 times of the lower when k = 0.75. Note that an inverting-type transformer model (M < 0 in Fig. 4.7) was employed to derive the equation, the upper cut-off frequency of the non-inverting-type transformer (M >0) diminishes due to the zero created by the nominator in Eq. (4.12). However, the general principle is still valid since the zero frequency is also a function of k as

$$f_z = \frac{1}{2\pi} \sqrt{\frac{k}{(1-k^2)\sqrt{L_p L_s} C_F}},$$
(4.16)

which increases with a larger k.



Figure 4.8: (a) Transformer structure, (b) coupling coefficient k simulation result, (c) self-inductances of L_p and L_s , and (d) quality factor Q of the secondary winding.

While Eqs. (4.15) and (4.12) provide insights in the design of a transformer, the accuracy, however, is compromised with such a simplified model. Similar to the on-

chip inductor design, the transformer also faces the issue of self-resonance due to the capacitive coupling to the substrate and the inter-winding parasitic capacitance. Electromagnetic simulation software such as HFSS and ADS Momentum is usually needed to investigate the performances of the transformer with good accuracy.

There are three commonly used transformer structures: tapped TF, interleaved TF, and stacked TF. The stacked structure features the highest coupling coefficient k but has the largest C_F . To reduce C_F , a two-turn staggered structure [65] is employed in this design, as depicted in Fig. 4.8a. The metal width and space of both the primary and secondary windings are set to be the same (4 μ m). By staggering the two windings, the overlap capacitance is minimized with only a slightly degraded coupling coefficient.

The simulation result of the coupling coefficient is depicted in Fig. 4.8b along with the self-inductance shown in Fig. 4.8c. As can be seen, the designed transformer obtains a coupling factor k of 0.77 to 0.85 from 3.1 to 10.6 GHz. The windings both have two turns with similar diameter, the winding self-inductances over the band of interest are almost the same. The transformer obtains a self-resonant frequency of 16.3 GHz, which is well above 10.6 GHz. Since the quality factor of the primary winding is not a concern in this design, the secondary winding is implemented with the top ultra-thick metal (M9) in the 65-nm 1P9M process. As can be seen from Fig. 4.8d, the quality factor of the secondary winding is larger than 10 from 3.1 to 10.6 GHz.

The post-layout simulation result of S11, from 3.1 to 10.6 GHz, is less than -10 dB, which indicates good input matching, as shown in Fig. 4.9. The differential gains S21 and S31 of the LNA are depicted in Fig. 4.10. As can be seen, the gains of the two paths are balanced with a flat in-band gain response. The maximum voltage gain for each path is about 16.3 dB, while the maximum difference in the 3.1-to-10.6-GHz band is about 1.2 dB. As shown in Fig. 4.11, the noise figure for the entire band of interest is about 3.4 to 3.7 dB.







Figure 4.10: Voltage gain the of the LNA.



Figure 4.11: Noise figure of the LNA.





Figure 4.12: (a) UWB transmitter and local template generator circuits, (b) new delay control circuit, and (c) signal flow of local template generator including integration-window generator.

The advantage of the correlation-based receiver over others is that the receiver can distinguish the transmitted signal from other in-band signals received by the antenna. The principle behind this is similar to that of a narrowband receiver, where the received signal is down-converted to baseband by the local oscillator (LO). Since the LO and the carrier signal share the same frequency, the other signals are ignored (filtered) by the narrow bandpass filter centered at the baseband. As the transmitted UWB signal in this research does not have a carrier, the "filtering" process, in this case, is accomplished by the local template generator which generates a UWB signal with the same shape as the transmitted one.

Of the two UWB pulse generators introduced in Chapter 3, the first design (Section 3.1) is utilized as the UWB transmitter for the UWB radar system due to its compact size and simpler structure. The transmitter circuit is redrawn here with a few modifications, as shown inside the dashed box in Fig. 4.12a. In the original transmitter, MOS varactors are used to adjust the delay between the inverters to control the width of the trapezoidal waves, the three delay cells (dark-gray box including a MOS varactor and two inverters) are replaced with the delay-control circuit, as shown in Fig. 4.12b. Compared to the MOS varactor method, the new delay-control circuit has a wider tuning range by employing PMOS current source to control the delay of the two inverters. Although the UWB transmitter and the receiver circuit share the same reference clock signal, the actual triggering time for the transmitter and local template generator can be different due to the different signal path lengths. For measurement calibration purpose, a delay unit controlled by $V_{ctrl.0}$ is added between the DLL and the local template generator to adjust the propagation time of the trigger signal, as depicted in Fig. 4.12a.

The modified UWB transmitter is then reused in the UWB receiver as the local template generator with two modifications, as shown in the dash-dotted box in Fig. 4.12a. Different from the UWB transmitter, the MOSFET sizes of the switch amplifier are modified to generate a UWB signal with about 1-V V_{pp} instead of 2.12 V. An integration-window generator is added to produce a square (trapezoidal) signal to control the integration time of the integrator, which will be further discussed in the correlator section. The window generator employs the same idea of generating the trapezoidal waves. Two falling edges from path1 and path2 are utilized, delayed, and combined with a NOR gate to make sure the start time of the integration window is the same as that of the template UWB signal. A delay-control circuit (Fig. 4.12b) is used in the integration-window generator to control the window size. In the template generator, the inverters, which interface with the integration-window generator, are resized so that the slope of the fall edges before the NOR gates in path1 and path2 are not affected. A simplified signal flow of the template generator, including the integration-window generator, is depicted in Fig. 4.12c. In order to generate a LO signal with the same shape as the transmitted UWB signal, the UWB transmitter and receiver share the same off-chip control voltages $V_{ctrl.1}$ and $V_{ctrl.2}$ so that the generated trapezoidal waves are identical. With a proper value of $V_{ctrl.3}$, the width of V_{int} from the integration-window generator can be adjusted to be approximately equal to the duration of the LO signal. As will be discussed in the section later, the correlator generates maximum output under such conditions.

4.4 Delay-Locked Loop Design

4.4.1 Phase/frequency Detector

Phase/frequency detector (PFD) is often used in phase-locked loop (PLL) or delaylocked loop circuits to generate outputs according to the detected frequency and phase difference of two input signals. The circuit shown in Fig. 4.13 is a good candidate with good performance.

The circuits are the same for the top and bottom paths. Taking the top path as an example, assume the initial condition of both CLK_{ref} and RESET are "LOW", then X would be "HIGH" and M_{p3} is off. If CLK_{ref} goes "HIGH", M_{p2} cuts off and M_{n2} turns on, discharging node A to "LOW". Similar behavior can be observed for the bottom path, where node B will drop to "LOW" when IN goes "HIGH". When both A and B are "LOW", RESET turns into "HIGH" and turns M_{n1} on discharging X to "LOW". With M_{p3} turned on and M_{n3} turned off, A (B also) is reset to "HIGH" and RESET goes to "LOW" again. Thus the PFD is only sensitive to the rising edge of



Figure 4.13: PFD circuit.



Figure 4.14: Timing diagram of the PFD.

the input signals, the time difference of the two rising edges is converted to the width difference of the output UP and DN signals, as shown in Fig. 4.14.

One issue of PFD is the blind zone, during which the PFD loses its ability to react to the input signals. One major cause of the blind zone is the reset process. To understand this issue, we take the upper path of Fig. 4.13 as an example. If a rising edge of CLK_{ref} arrives during the reset process when RESET is "HIGH", the output



Figure 4.15: PFD design in [66]

sate of A will not change to "LOW" because X is still discharged and kept "LOW" by M_{n1} . Thus the PFD will fail to sense the rising edge and may output wrong phase information. The issue is more severe as the operating frequency gets higher while the reset process occupies a larger portion of the clock period. To solve the problem, [66] proposed to reduce the effect of the reset process by adding a delay cell to shift the rising edge after the falling edge of the RESET signal (Fig. 4.15). It pointed out that the delay time has to be less than the time period from the rising edge of the latter input clock to the falling edge of the RESET signal to ensure proper operation. The pre-charging time for the parasitic capacitances also contributes to the blind zone [67], but the influence depends on the transistor size of the charge pump and the input frequency. As the reset time only occupies a small portion of the clock period in this research, the details are not discussed here.

Another issue of the PFD or the DLL circuit is the false lock problem. Generally, there are two types of false lock named harmonic lock and stuck false lock. The causes of both are essentially due to the same reason that the PFD can not distinguish between the rising edges of the reference clock signal. Under the correct lock condition,



Figure 4.16: PFD correct lock and harmonic false lock.

the DLL will lock the accumulated delay of the VCDL path (T_{VCDL}) to one period of the reference clock signal (T_{CLK}) . As depicted in Fig. 4.16, the reference clock signal (CLK_{ref}) leads the output signal of VCDL (IN) by one T_{CLK} , the rising edge of the two signals align with each other when locked.

Harmonic false lock can occur when T_{VCDL} deviates from the desired T_{CLK} to slightly larger than $2T_{CLK}$ due to temperature, noise, etc. The DLL will try to align CLK_{ref} and IN, and result in $T_{VCDL} = 2T_{CLK}$ rather than $T_{VCDL} = T_{CLK}$, as shown in Fig. 4.16. This is a major issue when the DLL has to work across a wide frequency range. Additional "detect and reset" circuitry is usually required to correct the false lock with extra design complexity, accompanied by extra circuit area and power consumption. Since the DLL in this research works only at one particular frequency, the harmonic lock issue can be solved by limiting the delay time of VCDL to a narrow range $(0.5 \cdot T_{VCDL}$ to $1.5 \cdot T_{VCDL})$ with no extra cost.

The stuck false lock can happen at the start-up of the DLL if the PFD decides a wrong phase relation between the CLK_{ref} and IN, as shown in Fig. 4.17. Note that the first rising edge of IN comes earlier than the second rising edge of CLK_{ref} $(T_{VCDL} < T_{CLK})$, which means that IN leads CLK_{ref} . However, the PFD falsely



Figure 4.17: PFD stuck false lock.



Figure 4.18: Correct stuck false lock by resetting at the falling edge of CLK_{ref} .

detects that CLK_{ref} leads IN, thus triggering the "UP" signal to the charge pump to further decrease the delay time of VCDL. As T_{VCDL} can not reach zero, the DLL gets stuck at the minimum possible T_{VCDL} . To solve the issue, another "RESET'" signal, which is triggered by the falling edge of CLK_{ref} , is added to the PFD design. As can be seen from Fig. 4.18, by resetting the PFD at the falling edge of CLK_{ref} , the PFD successfully generates correct output signals.

The schematic of the proposed PFD is depicted in Fig. 4.19. The proposed design combines the PFD in [66] with several modifications and added parts as follows: (1)



Figure 4.19: Proposed PFD with false lock prevention.

two-stage inverters (labelled "A" in Fig. 4.19) are used as the delay cell to reduce the blind zone of the PFD; (2) a narrow pulse generator (labelled "C") is used to generate the extra reset signal (RESET') at the falling edge of CLK_{ref} ; (3) a set of PMOS and NMOS transistors (labelled "B") are added to compose a NOR gate for the two reset signals; (4) two buffers (labelled " E_1 " and " E_2 ") with different transistor sizes are added to accommodate the unequal loading seen at the two inputs of the PFD; (5) two output buffers (labelled " D_1 " and " D_2 ") are inserted to interface with the charge pump to provide sufficient driving capability. The upper output of the PFD is inverted by " D_1 " to drive a PMOS transistor in the charge pump and the bottom path maintains its polarity to drive a NMOS transistor with " D_2 ". A transmission gate is used in D_2 to ensure that the two paths have the same delay time. It should also be noted that although another blind zone is introduced by the extra "RESET" signal, its duration (about 50 ps) is quite short compared with T_{CLK} (5.12 ns), thus it will hardly affect the functionality of the PFD.

4.4.2 Charge Pump

The charge pump and phase/frequency detector (phase detector) combination circuit has been widely used in various PLL and DLL applications [68][69][70]. Through sourcing or sinking current from the load capacitor, the charge pump converts the phase information sensed by the PFD to the control voltage of the VCDL.



Figure 4.20: (a) Charge pump circuit with the PFD block and load capacitor, and (b) waveform with phase difference and locked state.

A basic charge pump circuit is shown in Fig. 4.20a. The UP and DN signal from the PFD controls the upper switch of the current source from V_{DD} to the load capacitor C_{ctrl} and from C_{ctrl} to GND, respectively. Assuming CLK_{ref} leads IN by ΔT (Fig. 4.20b) and the minimum width of the switch signal is T_m , the voltage change of V_{ctrl} in one period is given by

$$\Delta V_{ctrl} = \frac{\Delta Q}{C_{ctrl}} = \frac{I_1 \cdot (\Delta T + T_m) - I_2 \cdot T_m}{C_{ctrl}}.$$
(4.17)

It can be expected that V_{ctrl} should be constant when the DLL is correctly locked, at which state CLK_{ref} aligns with IN ($\Delta T = 0$). Thus I_1 has to be equal to I_2 to obtain a ΔV of 0 in Eq. (4.17). Assigning $I_1 = I_2 = I_{cp}$, and taking the period of CLK_{ref} into consideration, Eq. (4.17) can be rewritten as

$$\Delta V_{ctrl} = \frac{I_{cp}}{C_{ctrl}} \cdot \Delta T = \frac{I_{cp}}{C_{ctrl}} \cdot (\frac{T_{CLK}}{2\pi} \cdot \Delta \phi), \qquad (4.18)$$

where $\Delta \phi$ is the phase difference of CLK_{ref} and IN in radians. Note that ΔV in each period is proportional to the phase difference $\Delta \phi$, the charging slope of V_{ctrl} during ΔT is $slope_1 = I_{cp}/C_{ctrl}$, as shown in Fig. 4.20b. If considering a minimum time unit of one T_{CLK} , or equivalently, assuming ΔV_{ctrl} continuously changes during one full period instead of only within ΔT , the charging slope of V_{ctrl} can be approximated as $(slope_2 \text{ in Fig. 4.20b})$

$$slope_2 = slope_1 \cdot \frac{\Delta T}{T_{CLK}} = \frac{I_{cp}}{C_{ctrl}} \cdot \frac{\frac{T_{CLK}}{2\pi} \cdot \Delta \phi}{T_{CLK}} = \frac{I_{cp}}{C_{ctrl} \cdot 2\pi} \cdot \Delta \phi, \qquad (4.19)$$

As will be discussed in the later section, I_{cp} and C_{ctrl} needs to be chosen to obtain a high corner frequency of the DLL.

Under an ideal situation, the charge pump can be perfectly balanced and will introduce no phase error. However, several practical issues of the charge pump design arise when implemented in circuits. One of the major issues is current mismatch. Take the charge pump in Fig. 4.21a as an example. M_{p2} and M_{n2} serve as the current sources while M_{p1} and M_{n1} are the switches, and V_{bp} and V_{bn} are the constant bias


Figure 4.21: (a) "Drain-switched" charge pump circuit, and (b) charge pump current matching characteristic.

voltages controlling the charge pump current. As the switches are located at the drain side of the current source, this topology is called the "drain-switched" charge pump. It can be immediately noted that the charge pump can not work for the whole 0 to V_{DD} output voltage range. The drain-source voltage has to be large enough for the MOSFETs to be in the saturation region to be seen as a current source. However, even when both M_{p2} and M_{n2} work in the saturation region, the current mismatch still exists due to the severe channel length modulation in modern nanometer technologies. Moreover, to make M_{p1} and M_{n1} better switches, transistors with large widths are also used, which deteriorates the feedthrough of the switch signal to V_{ctrl} through C_{GD} .

A common method of improving the current mismatch is to enlarge the output impedance of the current source with long channel transistors as a current source or with a cascode structure. The latter is usually unpractical in modern CMOS technology which has relatively low supply voltage. However, even with long channel length transistors, the maximum current mismatch of the charge pump can still easily exceed 10% of the designed current value as V_{ctrl} approaches near the boundary of the normal functional region (MOSFET can work in the saturation region).



Figure 4.22: (a) Charge pump circuit with improved current mismatch from [71], and (b) charge pump current matching characteristic.

To solve the current mismatch problem, [71] proposed a design with improved current matching characteristics, as shown in Fig. 4.22a. In the design, the switches were placed in series with the source of the current sources, thus it is called a "sourceswitched" topology. The current source in source-switched structure inherently has higher output impedance with source degeneration if assuming with the same current source sizes and switch sizes. Moreover, the feedthrough of the switch is also suppressed by the current source before the charge pump output. In addition to the topology advantages, an error amplifier was employed to further enhance the current matching performance by enforcing the constraint that the voltage at node REF follows (equals to) V_{ctrl} . Combining with the current mirror, the design was able to make $I_1 = I_2$ when the UP is "LOW" and $I_3 = I_4$ when the DN is "HIGH". Since $I_3 = I_4$, the charge pump achieved $I_1 = I_4$ regardless of V_{ctrl} . The current matching characteristic is shown in Fig. 4.22b, although the charge pump current deviates from the designed current value as V_{ctrl} changes, the current matching was greatly improved.



Figure 4.23: Charge pump with transit current mismatch and possible solution.

Considering the merit of the charge pump topology in Fig. 4.22a, it is adopted in the DLL design in this research. However, it was also found that although the charge pump exhibits excellent current matching in DC static state, the current mismatch still exists in transit analysis. The reason for such a mismatch was due to the bias voltage variation of the current source. For instance, as can be seen from Fig. 4.23, when the UP signal is "LOW" to open the top switch, the voltage jump of node Q will cause a jump at node X through C_{GS1} . Due to the finite output impedance of the error amplifier and the relatively large capacitance composed of C_{amp} (output capacitance of the error amplifier), C_{GS1} , and C_{GS3} , the time constant at node X can be relatively large, which results in a slow voltage rise and fall at node X. Consequently, the charging current features a slow response. A similar problem occurs at node Y of the bottom section. However, as the two nodes see different impedances and capacitances, the difference between the sourcing and sinking current can be quite large.



Figure 4.24: Proposed charge pump with improved current mismatch.

One way to solve the issue is by adding another capacitor to suppress the voltage variation, as demonstrated in the dashed box in Fig. 4.23. However, two capacitors have to be added between node X and V_{DD} and between node Y and GND, respectively. What is more, the added capacitors have to be quite large to take effect, which occupies a substantial chip area. We propose a way to suppress the voltage variation of the two nodes at the same time by adding a capacitor C_1 between them, as shown in Fig. 4.24. The basic idea here is that since the voltages of the two nodes change in

the opposite directions (jump-up at Q and jump-down at node S), the two variations can counteract each other by simply adding one capacitor in between, and a much smaller capacitor can meet the requirement. In the proposed design, the error amplifier is implemented with a two-stage differential-to-single-ended amplifier, as depicted in Fig. 4.24.



Figure 4.25: Current matching of the sourcing and sinking current.



Figure 4.26: Transit waveforms of the sourcing and sinking current with and without C_1 .

The current matching characteristics of the proposed charge pump are shown in Fig. 4.25. The sourcing/sinking current difference maintains less than 4 μ A when V_{ctrl} varies from 0.15 V to 0.75 V. The transit waveform of the charge pump sourcing

and sinking current with and without C_1 are depicted in Fig. 4.26. As can be seen, with C_1 added in the charge pump, the sourcing and sinking current achieve much better matching.

4.4.3 Voltage-Controlled Delay Line Design

One of the main advantages of the DLL over the PLL, when used for clock generation, is the ability to generate multiple phases. When the DLL is properly locked, CLK_{ref} and IN (two input signals of the PFD) should align with each other. The voltagecontrolled delay line provides a delay equal to one period of the clock signal T_{CLK} . Thus if the minimum delay of one stage in the VCDL is T_d , the maximum number of phases possible that the DLL can output would be $N = T_{CLK}/T_d$.

In a cross-correlation receiver, the sweep resolution of the receiver is determined by the minimum time step of shifting the local template signal. Thus one objective of the VCDL in this research is to design with small T_d . The total delay of the VCDL should be large to preserve enough time to process the received signal. Basically, if only one receiver path is employed, the output low-frequency signal of the receiver will have a time step equal to T_{CLK} . However, as the VCDL only serves the role of delaying the input clock signal, in other words, the DLL works at the same frequency as the reference clock. The total number of delay stages need to be large to work under a relatively low frequency $(1/T_{CLK})$ reference clock.

Questions raised in the design of the VCDL would be the choices of MOSFET sizes and the number of inverter stages.

Take the inverter chain shown in Fig. 4.27 as an example. The total delay of a M-stage VCDL equals to the sum of the delay per single stage (assume the inverters are identical) as $T_{VCDL} = M \cdot T_d$. Thus it can be noted that a VCDL with a specific T_{VCDL} can either be implemented with a small stage delay (small T_d) and a long chain (large M) or with a large stage delay and fewer number of stages. The purpose of the following analysis is to find the effect of the MOSFET size and the number of

stages on T_d and the noise performance of the VCDL.

In terms of the size of MOSFETs, let us use simple CMOS inverters as the delay cells in the VCDL, as shown in Fig. 4.28a. The external load of the inverter, such as the multiplexer, is ignored for now for simplicity purposes. The corresponding switch models of one inverter stage when the input voltage V_{IN} is "LOW" and "HIGH" are shown in Fig. 4.28b. When V_{IN} is "LOW", the PMOS can be modeled as an equivalent resistor R_{eqp} which conducts current to the load capacitor C_L with a current of I_{cp} . The NMOS is in the cutoff region and modeled as a switch in the OFF position. The opposite case occurs when V_{IN} is "HIGH", the NMOS is modeled as an equivalent resistor R_{eqn} discharging C_L while PMOS is modeled as a switch in OFF state. Thus the inverter stage can be treated as a first-order linear RC-network, and the propagation delay can be approximated as

$$T_d = 0.69C_L(\frac{R_{eqn} + R_{eqp}}{2}), \tag{4.20}$$

In practice, the value of the equivalent resistor changes during wave propagation as the MOSFET will go through both the triode and saturation region. Assuming PMOS and NMOS are sized to have equal equivalent resistance as $R_{eqp} = R_{eqn} =$ R_{eq} , the average on-resistance of the MOSFET can be expressed as

$$R_{eq} = R_{eqn} = \frac{1}{V_{DD}/2} \int_{V_{DD}/2}^{V_{DD}} \frac{V}{I_{dsat}(1+\lambda V)} dV \approx \frac{3}{4} \frac{V_{DD}}{I_{dsat}} (1-\frac{7}{9}\lambda V_{DD}), \qquad (4.21)$$



M-stage Delay Chain

Figure 4.27: *M*-stage delay chain.



Figure 4.28: (a) Inverter MOSFET circuit, and (b) the corresponding switch models when V_{IN} is "LOW" and "HIGH".

where λ is the channel-length modulation factor. I_{dsat} is the MOSFET current when working in saturation region, and can be expressed as

$$I_{dsat} = \mu_n C_{ox} \frac{W}{L} ((V_{DD} - V_{th}) V_{dsat} - \frac{V_{dsat}^2}{2}), \qquad (4.22)$$

thus it can be noted from Eqs. (4.21) and (4.22) that

$$R_{eq} \propto \frac{1}{W/L}.\tag{4.23}$$



Figure 4.29: Composition of load capacitance C_L at V_{OUT} .

Then what remains next is to find the value of the load capacitance C_L . The load capacitance is the sum of all the capacitances seen from V_{OUT} to GND (or V_{DD}). As

shown in Fig. 4.29, generally it is composed of in-stage gate-drain capacitance (C_{GDp0} , C_{GDn0}), in-stage gate-bulk capacitance (C_{DBp0} , C_{DBn0}), interconnecting-wire capacitance (C_w), and the fanout gate capacitance from the next stage (C_{Gp1} , C_{Gn1}), which includes the channel capacitance, gate-drain overlap capacitance and gate-source overlap capacitance. For simplicity, the wire capacitance and the gate-bulk capacitance are ignored here as the former relates to the layout structure while the latter depends on V_{OUT} and is quite nonlinear. As the overlap capacitance is proportional to the gate width W and the channel capacitance C_L can then be approximated as

$$C_L = A \cdot W + B \cdot WL, \tag{4.24}$$

where A and B are constant numbers. Note that although B actually varies as the MOSFET works in different regions, it is approximated here as an constant number, which indicates an average value. Thus the relation between the stage delay T_d and MOSFET width can be found by substituting Eq. (4.23) and Eq. (4.24) into Eq. (4.20) as

$$T_d \propto \frac{1}{W/L} \cdot (A \cdot W + B \cdot WL) = A \cdot L + B \cdot L^2.$$
(4.25)

It was shown in [72] that if the input period of the delay line is equal to the period of the corresponding ring oscillator (when closing the loop by connecting the input to the output of the delay line), then the white noise and flicker noise of M-stage inverters can be expressed as

$$S_{\Phi,white,DL} = \frac{\pi^2}{2I_D^2} \cdot \left[S_{I,NMOS}(f) + S_{I,PMOS}(f)\right] + \frac{2kT\pi^2}{I_D V_{DD}},\tag{4.26}$$

and

$$S_{\Phi,1/f,DL} = \frac{\pi^2}{4MI_D^2} \cdot [S_{\frac{1}{f},NMOS}(f) + S_{\frac{1}{f},PMOS}(f)], \qquad (4.27)$$

where I_D is the drain current of the MOSFET at operating point $|V_{GS}| = V_{DD}$ and $|V_{DS}| = V_{DD}/2$ (assuming same I_D for the NMOS and PMOS), k is the Boltzmann constant, T is the absolute temperature, and $S_I(f)$ and $S_{\frac{1}{f}}(f)$ are the thermal and flicker noise current spectrum (two-sided) of the transistors that can be expressed as

$$S_I(f) = 2kT\gamma g_m, \tag{4.28}$$

and

$$S_{\frac{1}{f}}(f) = \frac{K}{2WLC_{ox}f} \cdot g_m^2, \qquad (4.29)$$

where γ is the excess noise coefficient, g_m is the transconductance of the MOSFET, and K is a process-dependent parameter. Assuming equal γ and g_m for NMOS and PMOS, Eq. (4.26) and Eq. (4.27) can be rewritten as

$$S_{\Phi,white,DL} = \frac{2kT\gamma g_m \pi^2}{I_D^2} + \frac{2kT\pi^2}{I_D V_{DD}},$$
(4.30)

and

$$S_{\Phi,1/f,DL} = \frac{g_m^2 \pi^2}{8MLC_{ox} f I_D^2} \cdot \left[\frac{K_{NMOS}}{W_{NMOS}} + \frac{K_{PMOS}}{W_{PMOS}}\right].$$
 (4.31)

Assuming a MOSFET working in saturation region under the operating point of $|V_{GS}| = V_{DD}$ and $|V_{DS}| = V_{DD}/2$, we have the transconductance and drain current expression as

$$g_m = \mu C_{ox} \frac{W}{L} (V_{DD} - V_{th}) \propto \frac{W}{L}, \qquad (4.32)$$

and

$$I_D = \frac{1}{2} \mu C_{ox} \frac{W}{L} (V_{DD} - V_{th})^2 \propto \frac{W}{L}.$$
 (4.33)

Hence we can obtain from Eq.(4.30), and Eq.(4.31) that

$$S_{\Phi,white,DL} \propto \frac{L}{W},$$
(4.34)

and

$$S_{\Phi,1/f,DL} \propto \frac{1}{MWLf}.$$
(4.35)

We can draw a few useful conclusions from Eqs. (4.20), (4.25), (4.34), and (4.35) that:

(1) The single-stage T_d is independent of the MOSFET width, but it can be enlarged with a longer MOSFET channel length or by adding extra capacitance C_e to the inverter output node.

(2) For a specific T_{VCDL} , the white noise of the delay line is not a function of C_e and the number of stages: it depends only on the dimension of the MOSFET. One way to suppress the white noise (both resistor white noise and MOSFET thermal noise) is to employ MOSFETs with larger widths at the cost of higher power consumption.

(3) For a specific T_{VCDL} , the flicker noise is also independent of C_e , but is inversely proportional to the number of delay stages and the gate capacitance of the MOSFETs.



Figure 4.30: Voltage control delay line with multiplexer.

As mentioned at the beginning of this section, the design of the VCDL needs to accommodate the requirements of the high sweep resolution and large total delay. The research scopes to have a resolution less than 5 mm if applied over free space, a 256-stages inverter-based VCDL is employed, as shown in Fig. 4.30. The single-stage delay time is designed to be 20 ps while the total delay of the delay line is 5.12 ns, which corresponds to a 3-mm resolution and 76.8-cm single period detection range. The design considerations are listed as follows:

(1)A minimum MOSFET length is used to obtain a small T_d and flicker noise. The MOSFET width, on the other hand, is set to be larger than the minimum dimension to gain its driving capability (speed) due to the extra capacitance introduced by the multiplexer.

(2) Although, in theory, the amount of phase noise introduced at a rising edge is the same as that introduced at the falling edge, only rising edges are employed in this design for two reasons. The first is that the threshold voltage of the MOSFET is affected by the temperature and process variation. The inverting voltage may deviate from 0.5 V ($V_{DD}/2$) due to the threshold voltage change, leading to unequal delay time for the two consecutive delay steps. As T_d is only 20 ps in the design, the deviation can be significant. The second reason is that the falling-edge signal has to be inverted by an extra inverter to create a rising edge since the replica generator is only sensitive to rising edges. Although a transmission gate can be added after the rising-edge signal (out of the VCDL) to compensate for the extra delay introduced in the falling-edge case, it is difficult to perfectly match the delay difference of an inverter and a transmission gate.

(3) The adjustable delay is implemented by adding two additional NMOS transistors $(M_{n_1a} \text{ and } M_{n_1b})$ to the source of the delay unit (Fig. 4.30).



Figure 4.31: Simulation result of T_{VCDL} varying with V_{ctrl} .

The control voltage V_{ctrl} of the VCDL is applied to the M_{n_1b} to control the delay time by modifying the current of the two inverters. As mentioned previously in the design of the PFD, the delay time of the VCDL needs to be smaller than $1.5 \cdot T_{CLK}$ to avoid the false-lock problem. This is implemented here by connecting the gate of M_{n_1a} to V_{DD} to avoid cutting off the current of the delay unit when $V_c = 0$, thus limiting the maximum possible T_{VCDL} of the delay line. The post-layout simulation result of T_{VCDL} varying with V_{ctrl} is shown in Fig. 4.31. As V_{ctrl} changes from 0.15 V to 0.75 V, T_{VCDL} varies from 4.53 ns to 6.43 ns, which is within the desired range.

(4) In addition to limiting the slowest delay of the VCDL, it is also important to make sure that the VCDL can transmit fast enough as the desired delay per inverter is only 10 ps. It should be noted that the inverters are slowed down by the added transistors even when $V_{ctrl} = V_{DD}$ because V_{drain} would always be larger than 0, or it is equivalent to think that the inverters work under a lower V_{DD} . Note that the VCDL can not properly lock under $V_{ctrl} = V_{DD}$ due to the limited working range of the charge pump (Fig. 4.25). Instead of using both NMOS and PMOS to control the delay unit, which has the virtue of symmetric output waveform, only NMOS (M_{n_1a}, M_{n_1b}) is employed in this design to save the voltage headroom and ensure the speed of the delay unit. One issue still exists even with only NMOS is that the MOSFET size (M_{n_1b}) has to be quite large to obtain a low-enough V_{drain} . To resolve such an issue, the VCDL is divided into eight groups, inside of which the V_{drain} node of the delay unit are connected together. In this way, a more compact design can be obtained.

Before moving to the next section, it is worth mentioning a few more considerations regarding the number of stages and structure in the design of the VCDL. It is clear



(a)



Figure 4.32: (a) DLL design with single-chain 256-stage VCDL, and (b) DLL design with 16×16 coarse-and-fine step control.

from Eqs. (4.34) and (4.35) that the white noise of the VCDL is independent of the number of delay stages while the flicker noise decreases with more stages. But how about the power consumption and circuit area comparing to the type of VCDL with coarse-and-fine step control? Considering the two designs shown in Fig. 4.32 as examples. Both two examples have the same total delay of 5.12 ns and minimum delay step of 20 ps. The first DLL example (Fig. 4.32a) is the structure that is employed in the research, where the VCDL is composed of 256 stages of delay cells. The second DLL example (Fig. 4.32b) is a cascade design with a 16-by-16 coarse-and-fine phase division. The reference clock signal (CLK_{ref}) is first divided into 16 different phases with a delay step of 320 ps. Then the coarse signals are chosen by the multiplexer (MUX_C) to work as the reference signals for the fine DLL to generate 16 fine delays. It would be difficult to quantitatively evaluate which design is better without the practical design. Thus the two designs are only intuitively discussed and compared here.

As for the circuit area, the former design has 256 stages of delay cells, while the latter design has only 64 stages, which is three quarters less. The former design needs an 8-bit multiplexer to forward the selected signal to the output, while the latter design requires two 4-bit multiplexers. If both are implemented with 2-to-1 multiplexers, the multiplexer in the latter design takes about one-eighth of the area compared with the 8-bit multiplexer in the former design. However, two sets of PFDs and charge pumps (including the output capacitor) are employed in the latter design while the former only needs one. As the capacitors usually occupy a significant area, plus that extra area will be needed if the delay cells of the coarse DLL adopts extra capacitors or varactors to adjust the stage delay $T_{d,C}$, the circuit area of the two cases can be similar.

As for the power consumption, let us first assume that the delay cells $(D_1, ..., D_{256})$ of the former example are identical with the delay cells in the fine DLL of the second example $(D_{F1}, ..., D_{F16})$ since the single-stage delay time is 20 ps for both.

Then we can know from the design of a ring oscillator that the VCDL in the first example has the same power consumption as the VCDL_F in the fine DLL of the latter design (power consumption is independent of the number of stages of a ring oscillator). The PFD and charge pump of the former design basically has the same power consumption as the ones (PFD_C and charge pump_C) in the coarse DLL of the latter design as they work at the same frequency. As such, the power consumption of the latter design would be larger than the former one with extra power consumed by the coarse delay line (VCDL_C), and the PFD_F and charge pump_F of the fine DLL.

As for the noise performance, besides the aforementioned white noise and flicker noise of the VCDL, what has not been mentioned is that the PFD and charge pump also contribute to the phase noise of the DLL. For example, the phase noise of the PFD will modulate the width of the UP and DOWN pulses, which causes a mismatch between the sourcing and sinking current in the charge pump. Assuming that the PFD and charge pump introduce a phase error Φ_e into the DLL, which corresponds to a period difference of $\Phi_e/(2\pi \cdot T_{VCDL})$ seconds compared with the ideal case. For an ideal *M*-stage VCDL, the delay error of a single delay stage (T_e) can be calculated as

$$T_e = \frac{\Phi_e}{2\pi} \cdot \frac{T_{VCDL}}{M}.$$
(4.36)

As can be noted, a larger number of stages of VCDL is also beneficial to suppress the phase noise introduced by the PFD and charge pump. As such, the former design topology is employed in this research according to the reasons mentioned above.

4.4.4 Transfer Function of the DLL

Now that the sub-circuits of the DLL have been introduced, the design considerations of each part are discussed. It is worth deriving the transfer function of the DLL loop (Fig. 4.32a) to get the capacitance value of the charge pump load and finalize the DLL design.



Figure 4.33: (a) DLL model, and (b) DLL response.

As mentioned in the charge pump design (Section 4.5.2), the control-voltage $slope_2$ in Fig. 4.20b can be approximated as $I_{cp} \cdot \Delta \phi / (2\pi \cdot C_{ctrl})$. Thus the control voltage from the charge pump can be described as

$$V_{ctrl}(t) = \frac{I_{cp} \cdot \Delta\phi}{2\pi \cdot C_{ctrl}} \cdot t \cdot u(t), \qquad (4.37)$$

where u(t) is the unit step function. Then the transfer function of the charge pump (including C_{ctrl}) can be expressed as

$$\frac{V_{ctrl}}{\Delta\phi}(s) = K_{cp} \cdot \frac{1}{s} = \frac{I_{cp}}{2\pi \cdot C_{ctrl}} \cdot \frac{1}{s}.$$
(4.38)

Since the transfer function of the VCDL can be represented by K_{VCDL} , which is the delay line gain, and the PFD can be modeled as a subtractor, we can derive the transfer function from the DLL model, as shown in Fig. 4.33a. We can write

$$\phi_{out} - \phi_{in} = (\phi_{in} - \phi_{out}) \cdot \frac{I_{cp}}{2\pi \cdot C_{ctrl} \cdot s} \cdot K_{VCDL}.$$
(4.39)

Eq. (4.39) indicates $\phi_{out} = \phi_{in}$, which reveals an all-pass feature of DLL. It was described in [73] that the jitter transfer $|\frac{\phi_{out}}{\phi_{in}}|$ exhibits a small jitter peaking (Fig. 4.33b) since the DLL cannot distinguish between the jitter that modifies ϕ_{in} and that modifies ϕ_{out} . Note that the DLL generally faces no stability issues, and the jitter peaking can be reduced with a smaller loop gain $K_{cp}K_{VCDL}$. The charge pump current I_{cp} and load capacitor C_{ctrl} need to be chosen to balance the lock time and the jitter peaking.

4.5 Correlator Design

The previous sections introduce the LNA, which amplifies the weak UWB signal from the antenna, and the local UWB template generator, which is triggered by one of the clock signals from the DLL. In the correlator, the two signals correlate with each



Figure 4.34: (a) Correlator model, (b) integrator implemented with low pass filter, (c) integrator implemented with integration window controlled by switch.

other and generate a low-frequency (baseband) signal which contains the distance or location information that needs to be extracted in the baseband signal processing.

Generally, a correlator is composed of a multiplier and an integrator, as shown in Fig. 4.34a. This can be implied from the mathematical equation

$$f * g(\tau) = \int_{-\infty}^{\infty} f(t - \tau)g(t)dt, \qquad (4.40)$$

where f(t) and g(t) are the two input signals of the correlator, and τ is the displacement. As can be noted from Eq. (4.40), the output magnitude of the correlator reaches its maximum when the two input signals of the multiplier have the same shape and are exactly aligned with each other. This points out two essential design considerations of the correlation-based receiver that: (1) the shape of the local template signal needs to be as close to the received signal as possible to obtain optimum performance, and (2) the local template signal needs to be shifted in a very small time step to locate the position (delay time) the transmitted signal in order to have high accuracy and sweep resolution.

One way to implement the integrator is with a low-pass filter, as shown in Fig. 4.34b. As the transfer function of the low-pass filter can be expressed as

$$H(s) = \frac{1}{s/\omega_0 + 1},\tag{4.41}$$

where $\omega_0 = 1/(R_1 C_{int})$ is the corner frequency of the filter. When signal frequency ω is much higher than ω_0 , Eq. (4.41) can be simplified as

$$H(s) \approx \frac{1}{s/\omega_0} = \frac{1}{j\omega R_1 C_{int}},\tag{4.42}$$

which is the same as the transfer function of an integrator. To satisfy that $\omega \gg \omega_0$, C_{int} usually needs to be very large. With a large C_{int} , a waveform similar to charging and then discharging a capacitor can usually be observed for this type of integrator, as shown in Fig. 4.34b. One drawback for the integrator can be observed from the waveform is that the integrator can not hold the integration value, V_{out} starts to drop to the DC operating voltage V_{dc} (related circuit not shown) immediately after the integration time of the two signals, which produces a relatively narrow baseband output. Another drawback is that the peak amplitude V_{pk} is usually small since the voltage of a capacitor can be written as

$$V_{cap} = \frac{1}{C_{int}} \int i_{int} dt, \qquad (4.43)$$

which is inversely proportional to C_{int} .

To obtain a higher V_{pk} and a wider baseband pulse width, an integrator implemented by adding switch between the multiplier and the integration capacitor can be employed, as shown in Fig. 4.34c. Since the switch cuts off after the integration window, C_{int} holds the V_{pk} after integration until the reset switch discharges C_{int} to the initial voltage $V_{initial}$. The current is directly integrated by a smaller C_{int} , the V_{pk} can also be higher.



Figure 4.35: Correlator topology.

As for the multiplier design, the Gilbert mixer [74] proves to be a good candidate that has been widely used in radio frequency or millimeter-wave circuit design. A single-balanced Gilbert mixer is employed in this research to implement the multiplication of the local template UWB signal and the differential UWB signals from the low-noise amplifier. The correlator topology is depicted in Fig. 4.35. To measure the differential output signals of the correlator on an oscilloscope, two unity-gain buffers composed of M_{p4a} (M_{p4b}) and M_{n4a} (M_{n4b}) are added after the correlator to drive the oscilloscope. To obtain a high V_{pk} , the design adopts C_{GS} of M_{p4a} and M_{p4b} as the integration capacitors C_{int} with no extra capacitance added. The integration-window signal comes from the local template generator, as described in Section 4.3. Note that during each time when the switches (M_{n3a} and M_{n3b}) are ON, the output voltage (V_{out}) will be pulled back to the common DC voltage V_{cm} before the switches, which is similar to resetting V_{out} to $V_{initial}$. The reset paths can thus be eliminated, and V_{out} can have a pulse width of about one period of the DLL clock signal. Since C_{int} is quite small in the proposed correlator, which means that C_{int} can be quickly discharged, it is critical that the integration window be no wider than the UWB pulse duration. In the simulation, the integration window size is adjusted to be a little narrower than the UWB pulse width for optimum performance.

4.6 UWB radar system implementation and simulation

As mentioned at the beginning of this chapter, to utilize the most of the 3.1-to-10.6-GHz link margin without violating the FCC limitation, the pulse repetition period of the transmitted UWB signal should be limited to about 30 ns, which is about six times larger than the period of the DLL clock signal. Since the output clock signal of the DLL is periodic, the trigger frequency of the transmitter is adjusted to be 1/6 of the DLL reference frequency with a frequency divider to accommodate the conflict. Under this condition, the detection range of the UWB receiver is also extended to be six times longer with the same sweep resolution. The signal flow of the UWB radar system is demonstrated in Fig. 4.36. The layout of the UWB radar system is shown in Fig. 4.37 with an area of about 1.1 mm². Assuming a 40-dB loss for the transmitted UWB signal (including the gain of the antennas and the loss introduced by signal transmission in air, cable and signal reflection) and a changing rate of every 6×5.12 ns for the multiplexer control voltage, the simulation results







Figure 4.37: Layout of the UWB radar system.

of the local template signal and the RF_1 after the LNA are shown in Fig. 4.38a. A zoomed section of the two signals with a duration about six times of T_{VCDL} is shown in Fig. 4.38b. The difference of the two low-frequency output signals from the correlator is depicted in Fig. 4.38c. As can be seen, a maximum positive pulse can be successfully identified. The corresponding transmission time of the UWB signal thus can be obtained, according to the control voltage of the multiplexer, to calculate the distance between the antennas and the scatterer.

Table 4.1 summarizes the power consumption of the sub-circuits in the proposed UWB radar system. It can be noted that the LNA consumes the most power in the UWB receiver circuit. Although the UWB transmitter and the local template generator utilize the same topology (with minor modifications), the latter has a higher power consumption because of the higher trigger frequency.



Figure 4.38: (a) Simulated local template signal and RF_1 signal (one output from the transformer), (b) zoomed local template signal and RF_1 signal with duration about $6 \times T_{VCDL}$, (c) the difference of the output signals from the correlator.

	UWB Radar Receiver			
UWB Transmitter	LNA	Local Template Generator	DLL	Correlator
$0.3 \mathrm{~mW}$	$9.3 \mathrm{mW}$	$0.67 \mathrm{~mW}$	$3.2 \mathrm{mW}$	4.2 mW^*

Table 4.1: Power consumption summary of the sub-circuits in the proposed UWB radar system.

 * Include the power consumption of the correlator 0.2 mW and buffer stage 4 mW.

In the measurement stage, calibrations have to be undertaken before applying the radar system for breast cancer detection. First, the width τ_w and delay τ_d of the input two consecutive trapezoidal waves have to be properly set to make sure that the transmitted UWB signal satisfies the FCC mask. Second, the width of the integration window has to be tuned to obtain an optimum output amplitude when the received UWB signal aligns with the local template. Third, the difference of the propagation time between the transmitted UWB signal and the local template has to be compensated to ensure that the first tap of the DLL (00000000 control voltage for the multiplexer) works at a proper distance. Finally, the range accuracy needs to be calibrated in air by shifting the target precisely and calibrating the corresponding measurement results.

4.7 Summary

This chapter presents the design of a UWB radar system. The UWB pulse generator proposed in Chapter 3.1 is reused as the UWB transmitter. In the UWB receiver design, a three-stage, single-ended to differential, UWB LNA is first described. Employing a resistive-feedback CS structure, from 3.1 to 10.6 GHz, the proposed LNA achieves inband gain of 15.7 ± 0.6 dB for both paths, less than -10 dB S11, and 3.55 ± 0.15 dB NF. The local template generator is presented next. Same structure of the UWB transmitter (with modifications) is employed since the local template signal is desired to obtain the same waveform as the transmitted signal. Then the DLL, which

is designed to generate multiple-phase signals with small step size, is introduced. The DLL circuit contains three sub-circuits: PFD, charge pump, and VCDL. A PFD circuit is proposed to resolve the false lock problem with an additional reset signal at the falling edge of the reference clock. In the proposed charge pump design, the transit current matching performance is improved by adding a capacitor, between the gates of the sourcing and sinking current sources, to counteract the voltage jump. In the proposed VCDL design, a 256-stage current-starved inverters chain with a 8-bit multiplexer is employed. The step size and period of the DLL are 20 ps and 5.12 ns, respectively, which correspond to a sweep resolution of 3 mm and single-period sweep range of 76.8 cm in air. Finally, a single-balanced Gilbert mixer is employed as the multiplier. With a switch-capacitor integrator, the correlator can hold the outputs on the capacitor, which benefits the correlator with low-frequency output signals.

The system simulation results show that the UWB radar system can successfully obtain the transmission time of the UWB signal. The single-chip UWB radar system circuit, including the UWB transmitter and the cross-correlation receiver, was implemented in TSMC 65-nm technology with an area of about 1.1 mm².

Chapter 5 Conclusions

This dissertation has focused on the design of a fully-integrated UWB radar system that is capable of working as a microwave imaging system for the detection of breast tumors. Through the development of the proposed UWB imaging system, several contributions have been made by introducing advanced circuit-level techniques to enhance the performance of the UWB radars, as detailed in Section 5.1. The future steps for completing the design of the proposed UWB imaging systems are listed in Section 5.2.

5.1 Summary of Contributions

In Chapter 2, commonly used topologies of UWB pulse generators (transmitters) and UWB receivers in CMOS technology are described and discussed. For a pulse radar system with a specific working range, the SNR at the receiver antenna can be enhanced by increasing the transmitted power. To achieve better performance, the UWB transmitter designs focused on high output power and low complexity. Among the commonly used methods of UWB signal detection, cross-correlation detection was chosen as the receiver topology due to its immunity to interference, low complexity, and high resolution.

As CMOS technology advances towards nano-scale dimensions pursuing higher transit frequencies and lower power consumption in digital circuits by reducing the supply voltage, designing UWB pulse generators that achieve high output amplitude becomes more challenging. Chapter 3 presents two single-chip, high-voltage UWB pulse generator designs in 65-nm CMOS technology.

In the first design [75], the UWB signal is synthesized with two consecutive trapezoidal waves using digital circuitry so that it produces spectral notches at the desired lower and higher frequencies. To drive a 50- Ω load, the signal is fed to an inductorloaded power amplifier, which boosts the amplitude of the signal beyond the supply voltage while preserving the spectral features of the generated signal. Then the amplified signal is passed through a simple output network, which requires only four passive components including the load inductor. The simple output network does not attenuate the UWB signal noticeably as opposed to the high-order filters required in the conventional designs. The proposed UWB pulse generator achieved a peak-topeak amplitude of 2.12 V, which is 212% of the supply voltage. It was reused in the design of the UWB radar system for breast cancer detection.

In the second design [76], the passive amplification technique is extended from the narrowband to the wideband case demonstrating that a wideband signal still can be passively amplified, although with a smaller gain than the case of a narrowband signal. In the proposed UWB pulse generator design, a trapezoidal waveform is used as the input to the switch-mode power amplifier to produce the desired spectral notch in the output spectrum. A passive amplification network, including the finite inductor load, is designed to achieve impedance matching when the MOSFET of the power amplifier is both ON and OFF. However, a tradeoff has to be made to balance the matching performance at the two states. The proposed pulse generator achieved a 249% pulse peak-to-peak amplitude to supply voltage ratio; the highest among UWB pulse generators reported in the literature to the date of this publication.

Chapter 4 presents the design of a fully integrated cross-correlation UWB receiver in CMOS technology. The receiver is comprised of an ultra-wideband LNA, a local template UWB signal generator, a DLL (composed of PFD, charge pump, and

VCDL), and a cross-correlator (including a multiplier and an integrator). The designed LNA achieves a wide bandwidth of 3.1-10.6 GHz, low NF, and a high and flat inband gain. The local template generator is designed to generate a UWB signal the same as the transmitted one. The PFD design is focused on solving the false lock problem while the charge pump provides better matching between the sourcing and sinking currents. The VCDL is designed to generate multiple signals with a small step size and large period. The correlator design is focused on high output amplitude and low output frequency. Since the sweep resolution of the cross-correlation receiver is directly related to the time step of shifting the local template signal, an inverter-chain VCDL is adopted in the delay-locked loop design to provide a step size of 20 ps and a period of 5.12 ns. The same UWB transmitter topology (with minor modifications) is employed in the local template generator to produce a replica of the transmitted signal. To achieve better performance, the UWB receiver adopts a differential structure. A transformer is employed in the design of the LNA to convert the received single-ended UWB signal to differential signals. Single-balanced Gilbert mixer and switch-capacitor integrator are utilized to cross-correlate the received UWB signal with the local template. The UWB receiver is designed and integrated with the transmitter circuit into a single chip occupying an area of 1.1 mm^2 . The simulation results demonstrate that the UWB radar system can successfully identify the signal transmission time from the low-frequency output signals.

5.2 Future Work

The research has been focused on implementing the radar circuit part of the UWB imaging system. The other two parts, including the antenna array design and the image-reconstruction algorithm, are the next steps to work on.

In the design of the UWB radar circuitry, the antenna has been assumed to be an ideal 50- Ω resistor. However, in practice the impedance of a wideband antenna changes with frequency. The varying resistance and reactance of the antenna have to be considered in the system design to obtain optimum performance. Antennaand-circuit co-simulation will be needed to accommodate the antenna impedance and other uncertainties introduced by the components outside the chip, such as PCB board losses and parasitics.

The functionality of a simple UWB radar system, which includes the radar integrated circuit, the co-designed single antenna pair, and the image-reconstruction algorithm, will first be verified. The simple radar system will then be applied to image a breast model with an array of antenna pairs working as the UWB radar imaging system. The breast model will be constructed using a material with dielectric properties similar to fatty breast tissue. A sphere-shaped object with dielectric constant several times larger than the surrounding material, simulating a tumor, will be inserted in the breast model. The proposed imaging system will be used to reconstruct the image of the breast model to verify its functionality. Assuming the imaging of the breast model is a success, further plans will be laid out for clinical trials for UWB imaging of the human breast.

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